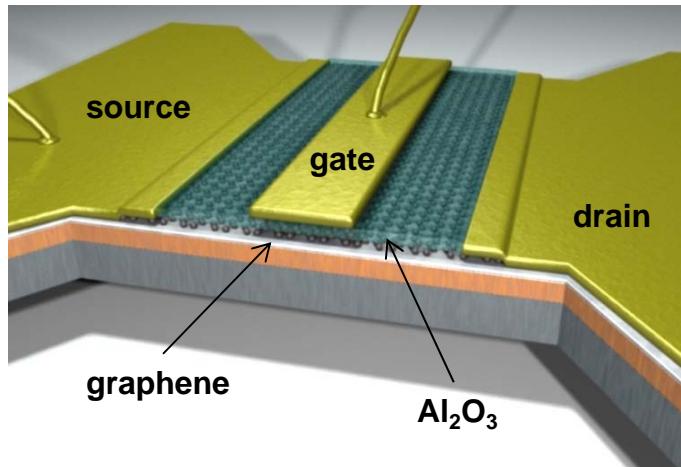


# Microwave Graphene Electronics



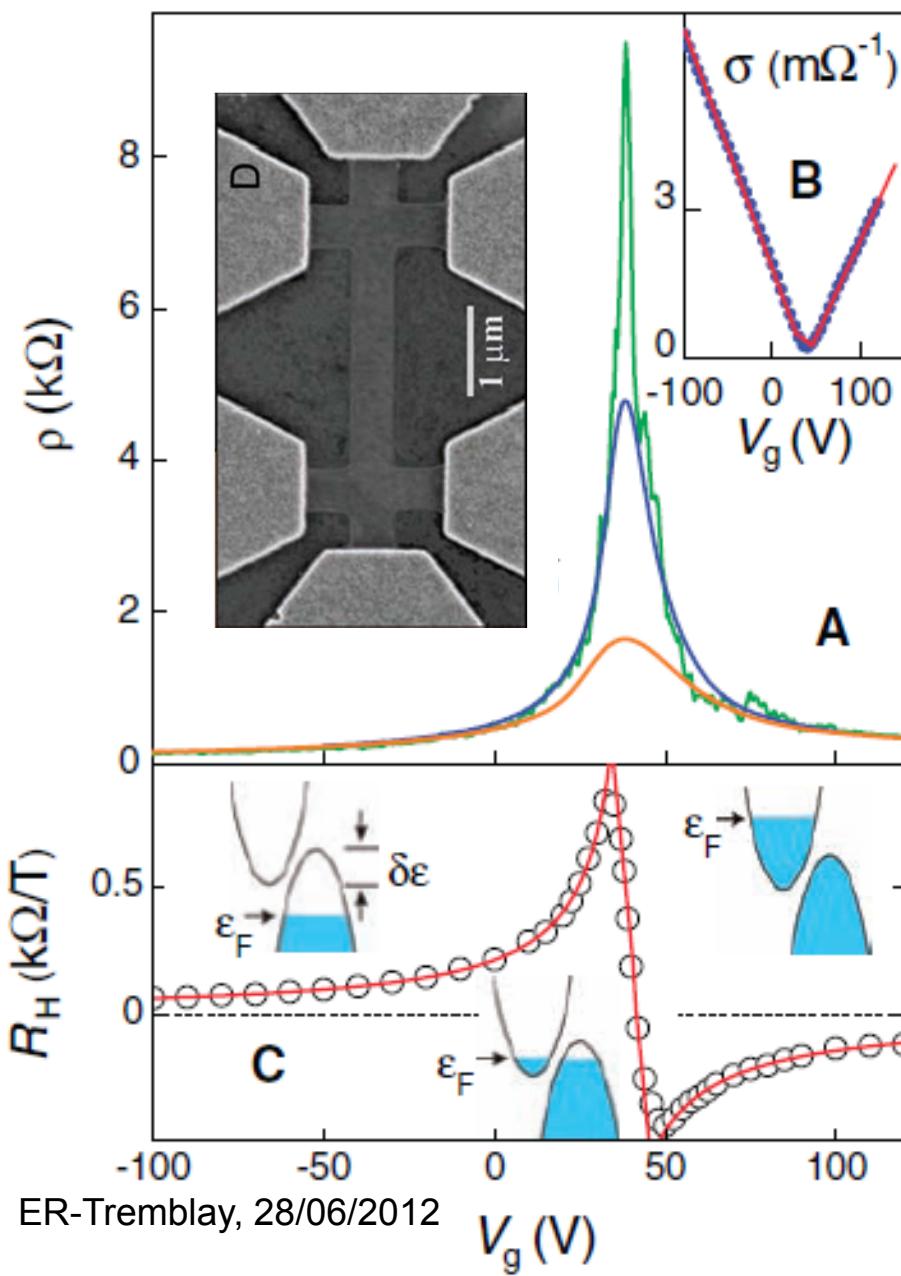
B. Plaçais

Laboratoire Pierre Aigrain – Ecole Normale Supérieure  
24 rue Lhomond, 75231 Paris Cedex 05 France

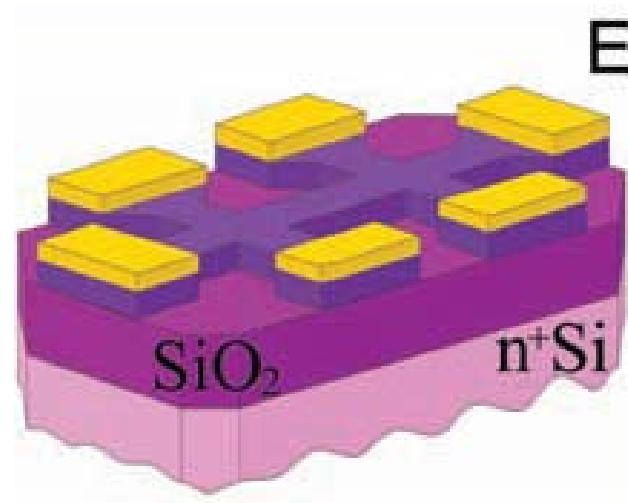
[www.lpa.ens.fr](http://www.lpa.ens.fr)

ER-Tremblay, 28/06/2012

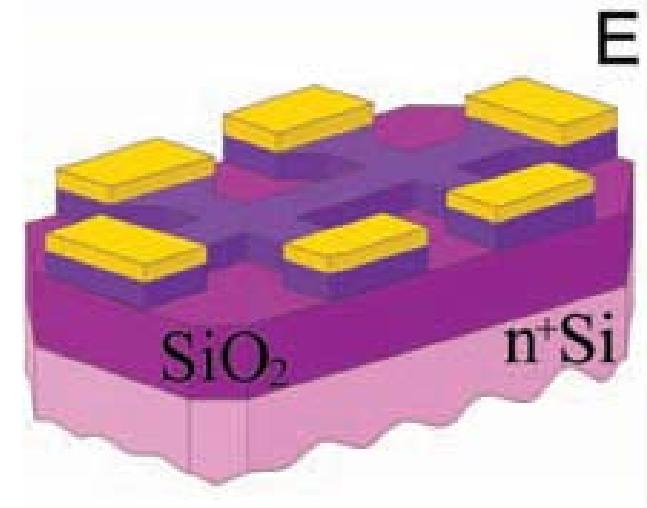
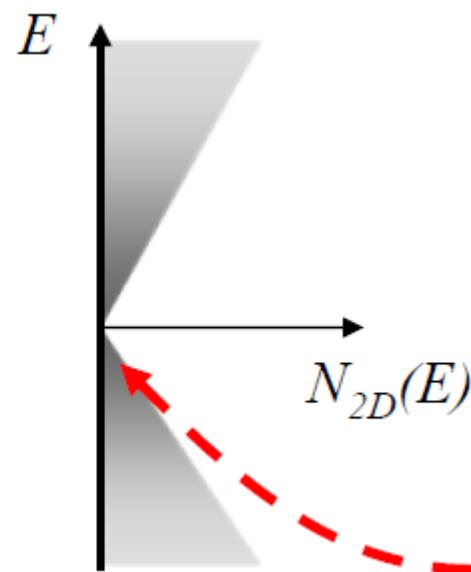
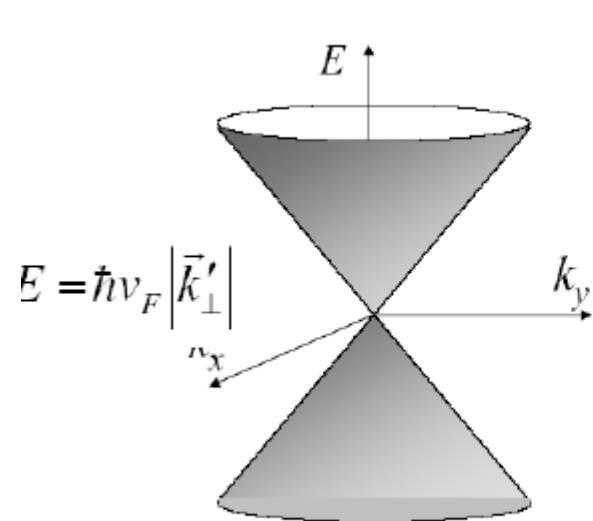
AGENCE NATIONALE DE LA RECHERCHE  
**ANR**



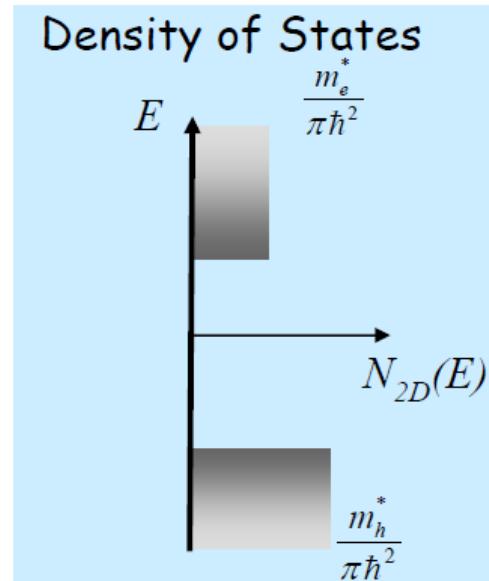
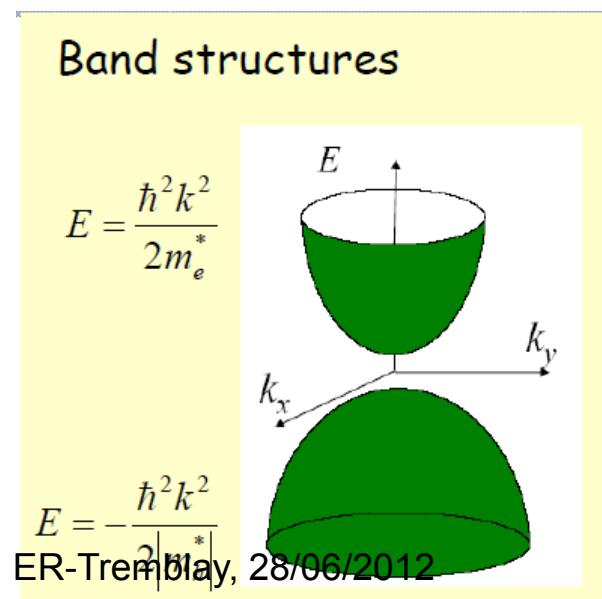
(K. Novoselov et al., Science 2004)



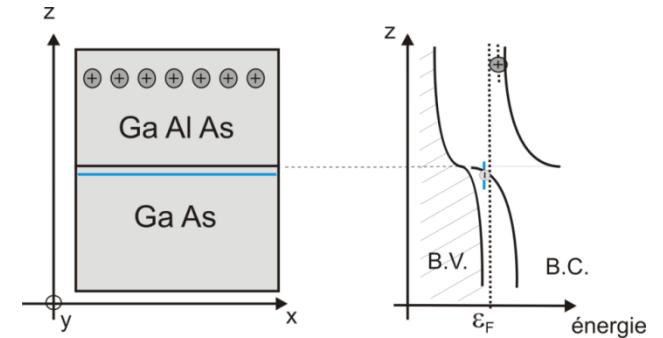
# An exceptionnal 2D metal !



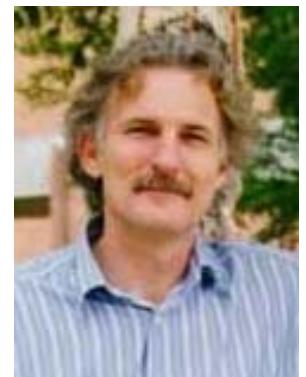
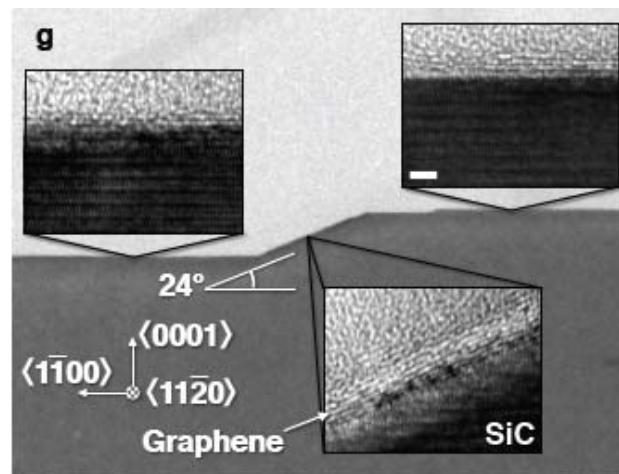
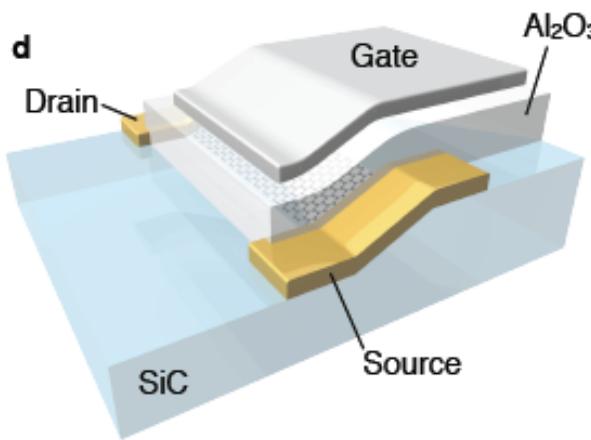
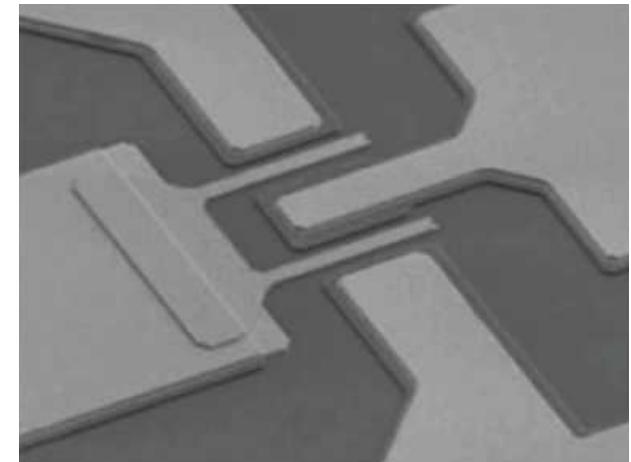
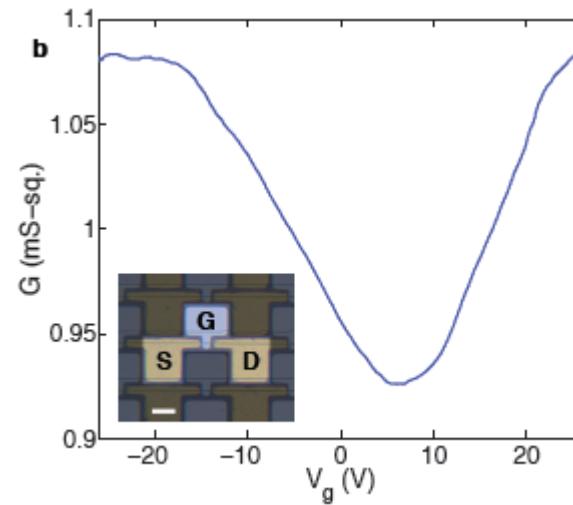
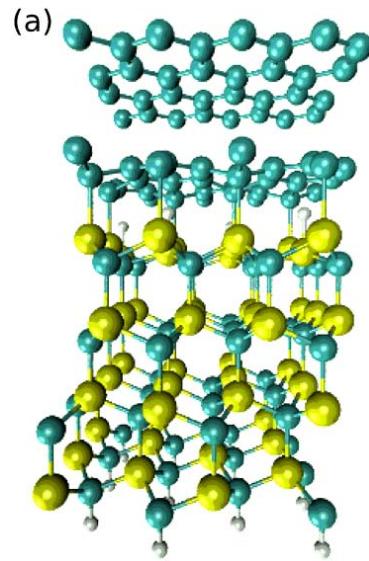
**Dirac point**



Semi-conducteur classique

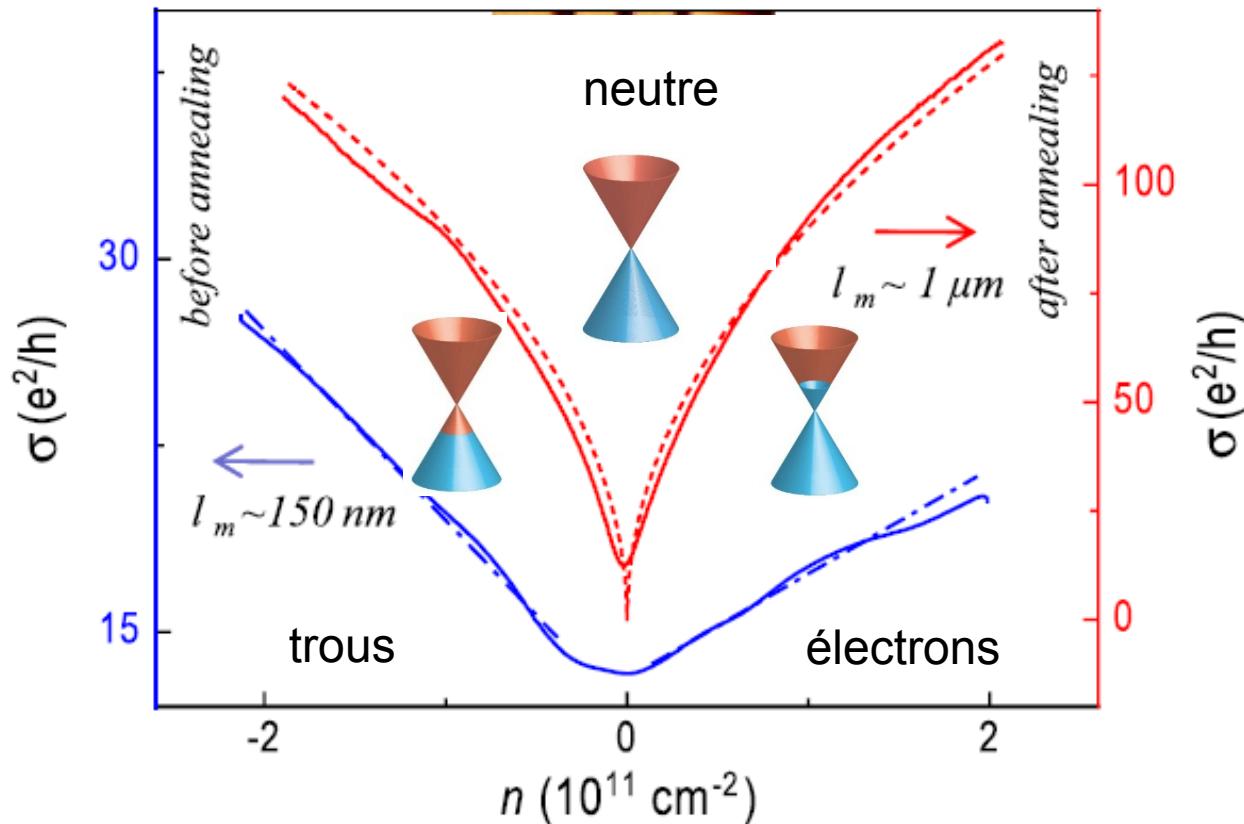


# Large scale epitaxial graphene

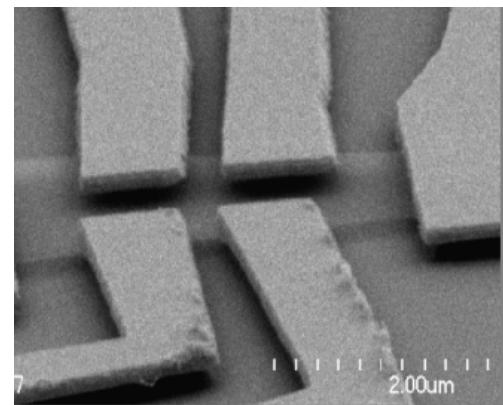


*(C. Berger and W. de Heer)*

# Field-effect in suspended graphene

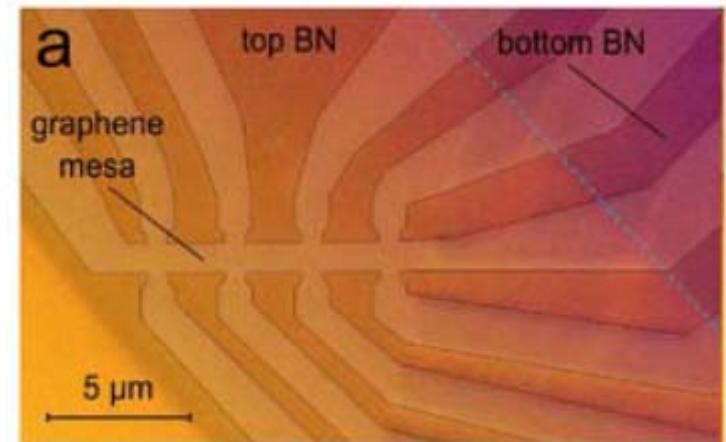
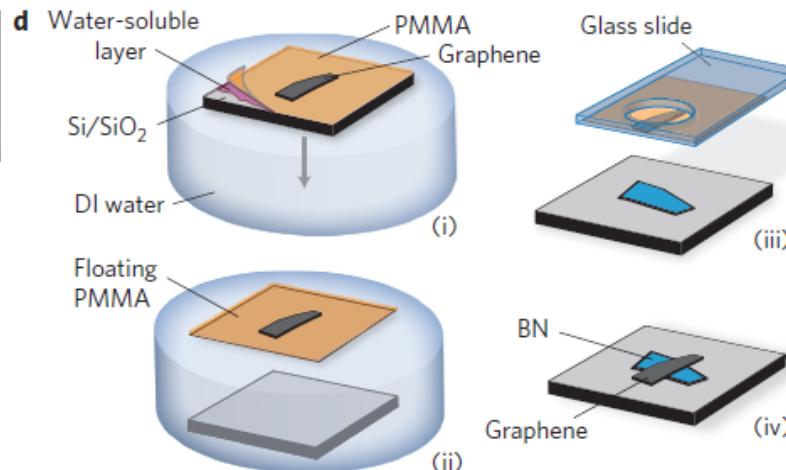
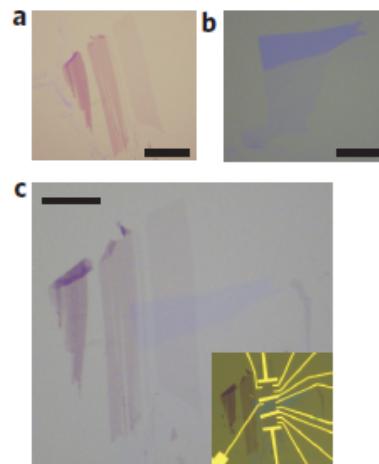
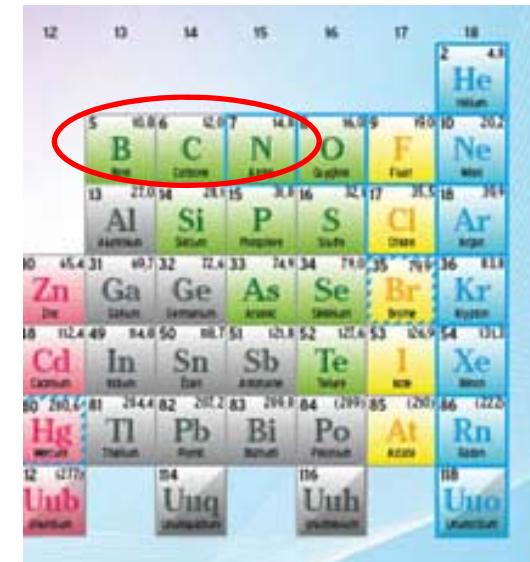
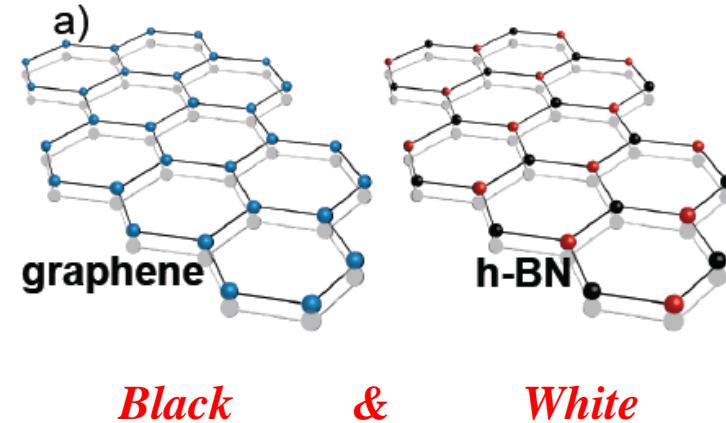


(Bolotin et al. PRL2008)



1. Importance of cleaning by current annealing
2. Efficient field effect in layered conductors
3. Tunable metal : broad range of electron and hole doping
4. Dirac fermion physics : conductivity at neutrality  $\sim 4 \text{ e}^2/\text{h}$

# Layered Graphene on layered Boron Nitride

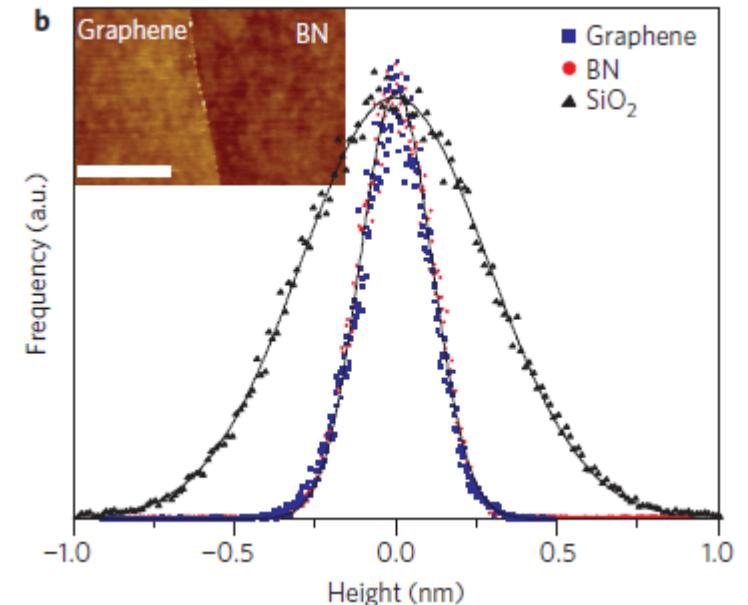
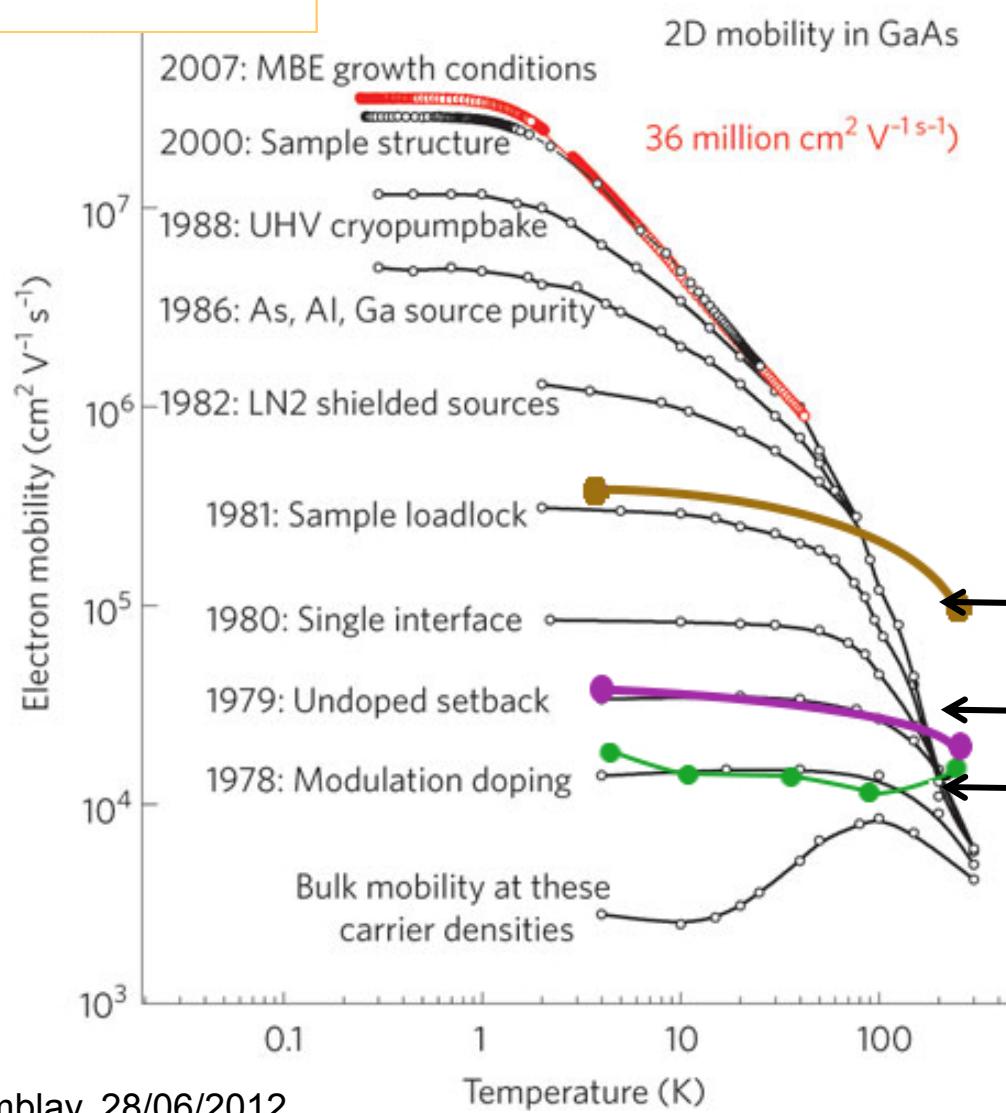


ER-Tremblay, 28/06/2012 (*Columbia, 2010*)

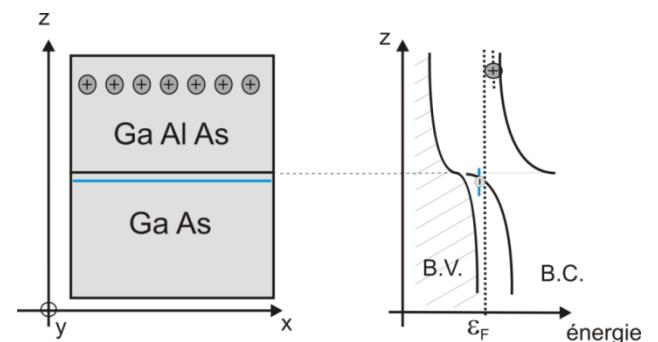
(*Manchester, 2011*)

# mobility/conductivity at room temperature

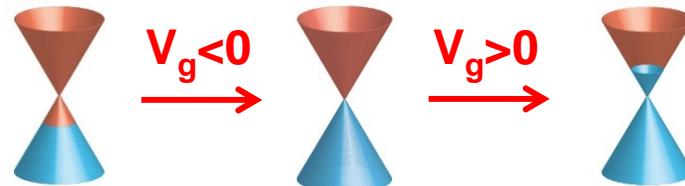
$$\mu = \frac{v_d}{E} ; \quad \sigma = n e \mu$$



(encaps., Manchester, Nanolett.'2011)  
(flake on BN, Columbia Nnano'2010)  
(CVD on BN, Berkeley, APL' 2011)



# List of key-numbers about graphene



✓ Gate tunable

e-concentration	$n_s = 10^{11}-10^{13} \text{ cm}^{-2}$	(symmetry)
chemical potential	$E_F = \pm 350 \text{ meV}$	(from Cr to Pt)
e-color	$\lambda_F = 10-100 \text{ nm}$	(e-quantum optics)
compressibility	$e^2\kappa = 10-100 \text{ fF } \mu\text{m}^{-2}$	(Q-capacitance)

✓ high mobility

$0.002 \rightarrow 20 \text{ m}^2\text{V}^{-1}\text{s}^{-1}$  (!! Dirac Fermions)

✓ Finite residual conductivity :

$4e^2/h = (6,45 \text{ kOhms})^{-1}$  (! quantum tunneling)

✓ Large Fermi velocity :

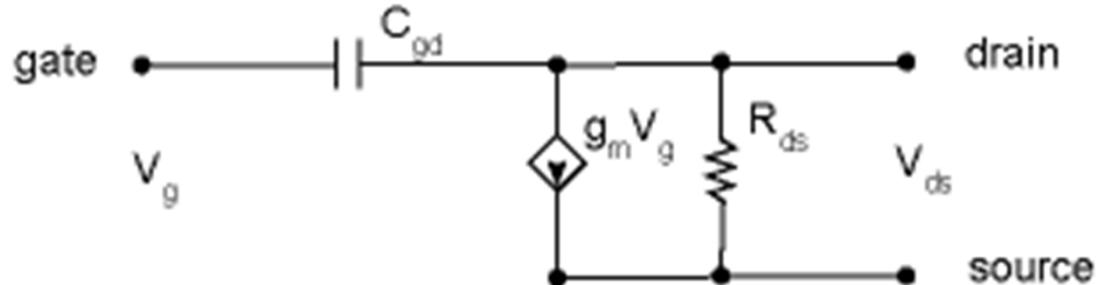
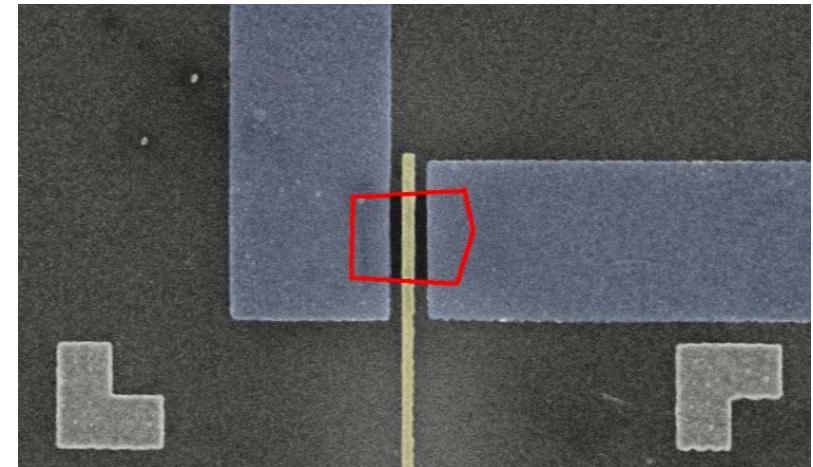
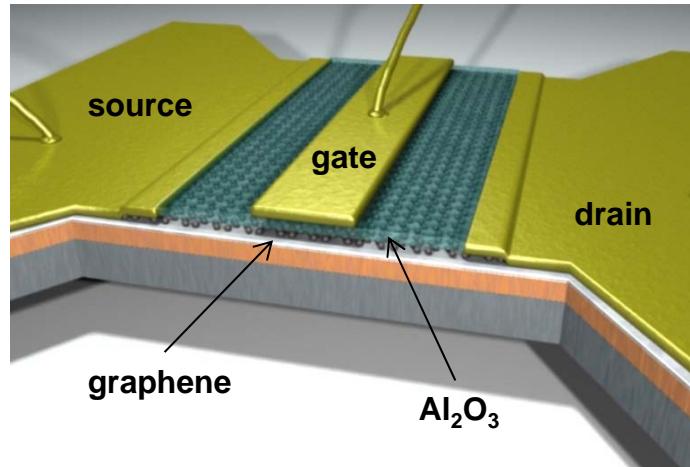
$v_F = 1, 10^6 \text{ m/s}$  (Magic carbon-bond !)

✓ Large sound velocity :

$c = 2. 10^4 \text{ m/s}$  (Magic carbon-bond !)

- 1) Introduction to magic graphene
- 2) Transit frequency of microwave transistors
- 3) Diffusion probed in a field-effect capacitor
- 4) Acoustic phonons controls noise of resistors
- 5) New transistor architectures

# Microwave Field Effect Transistor (FET)



Drain-source resistance  $R_{ds}$   
 Transconductance  $g_m$   
 Gate-drain capacitance  $C_g$

$$g_m = \frac{\partial I_{ds}}{\partial V_g} = W \frac{V_{ds}}{L} \frac{\partial n_e}{\partial V_g} \times \mu = W \frac{V_{ds}}{L} \frac{C_g}{LW} \times \mu$$

$$f_T = \frac{g_m}{2\pi C_g} = \mu \times \frac{V_{ds}}{2\pi L^2} = \frac{D}{2\pi L^2} \frac{eV_{ds}}{E_F} \leq \frac{D}{2\pi L^2}$$

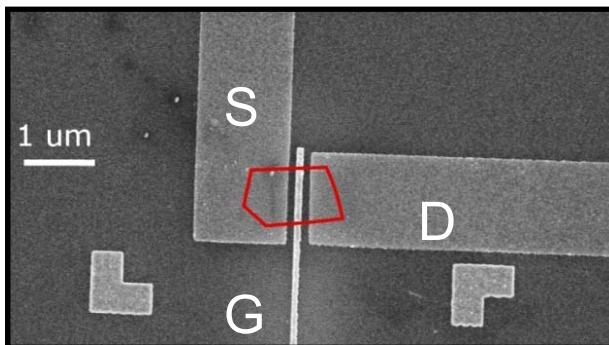
# Measuring microwave devices

80 GHz transistor (S-parameters)

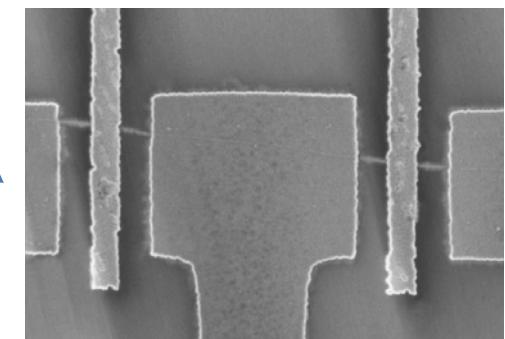
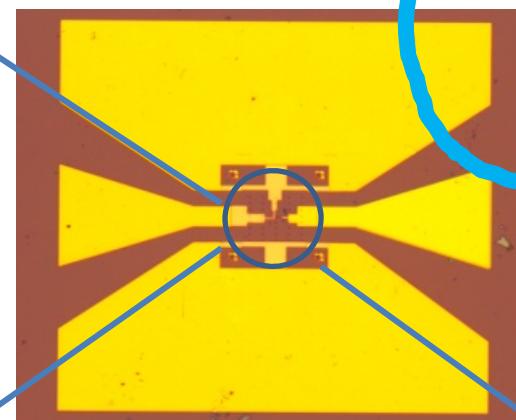


E. Pallecchi et al, APL 99, 113502 (2011)

16 GHz nano-transistor (S-paramters)

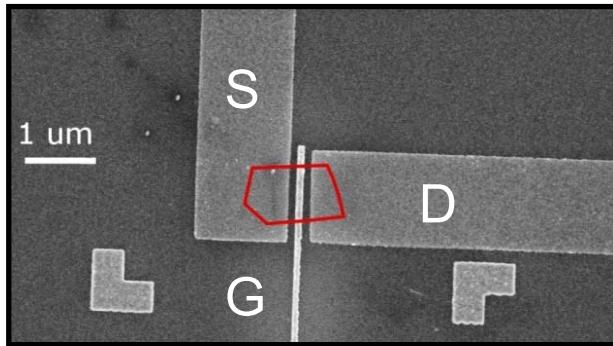


Wave guide (CPW)



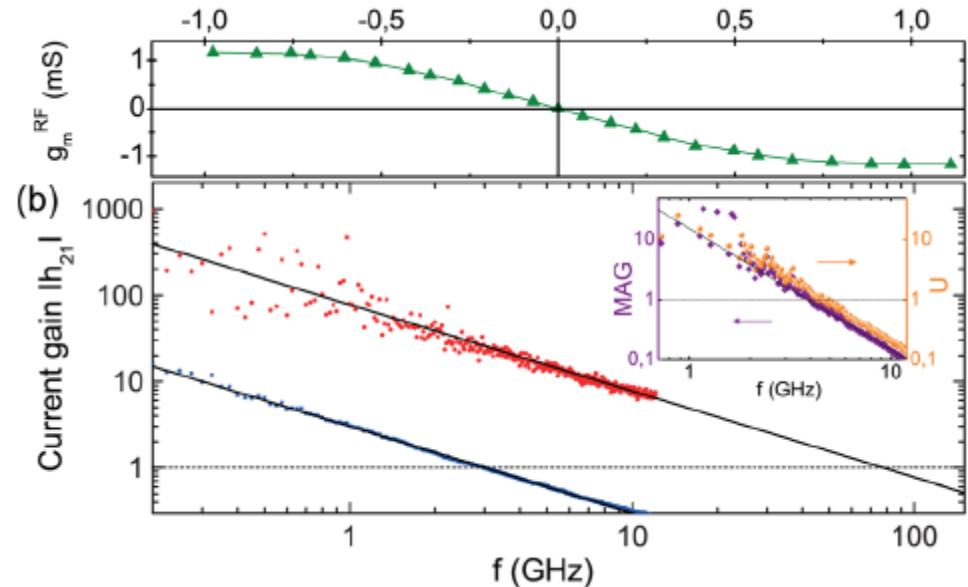
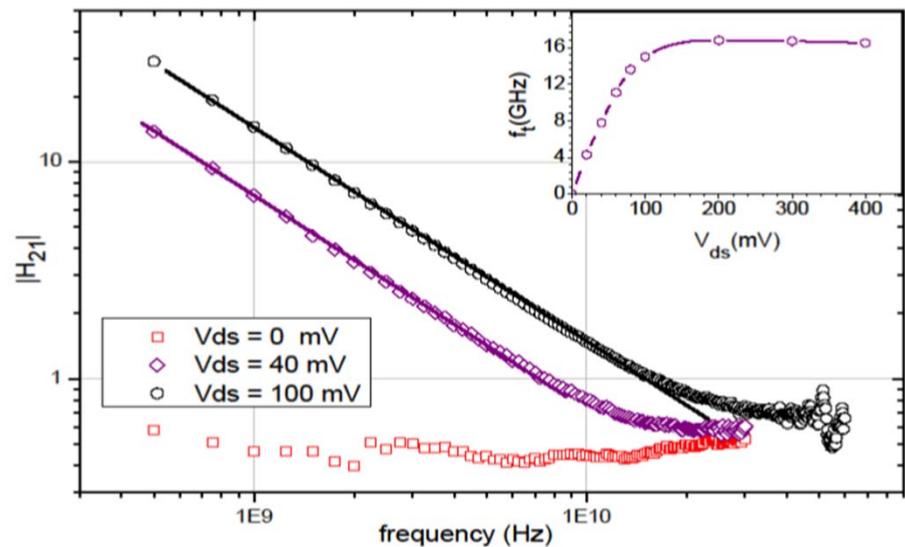
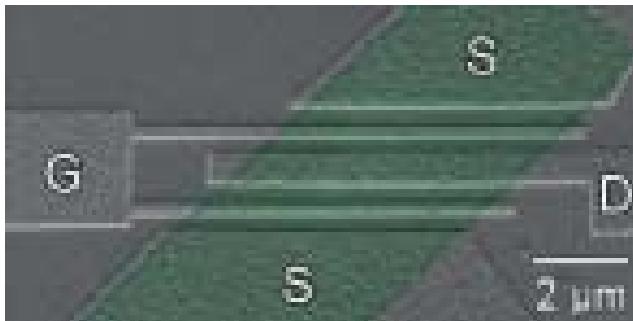
# Transit frequency measurement

Exfoliated GR on SiO<sub>2</sub> : 16GHz

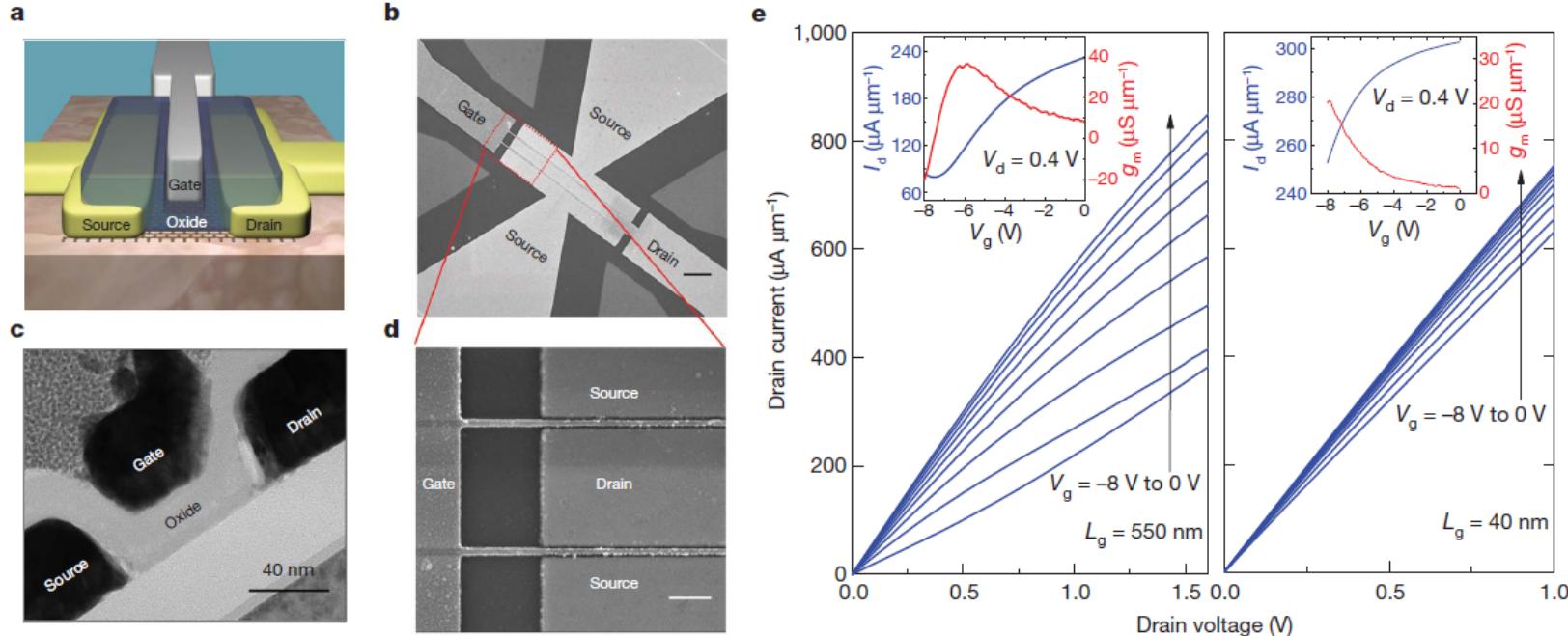


$$\text{current gain : } H_{21} = 1 + j \frac{f_T}{f}$$

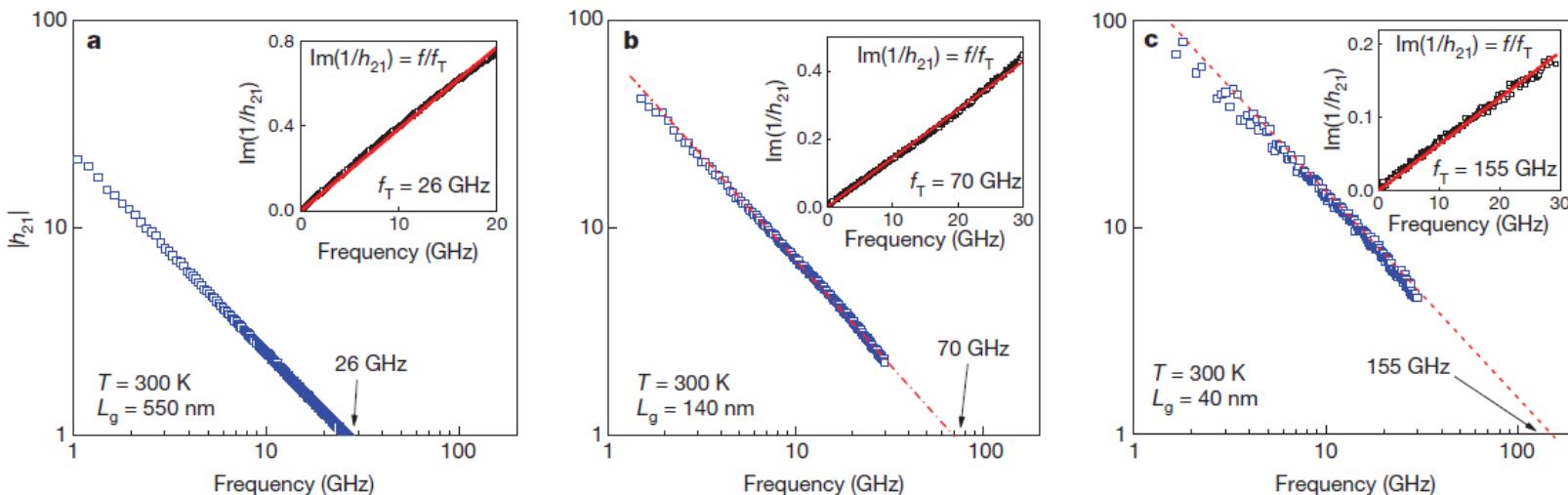
Exfoliated GR on Sapphire : 80GHz



# Kings of microwave transistors (IBM)

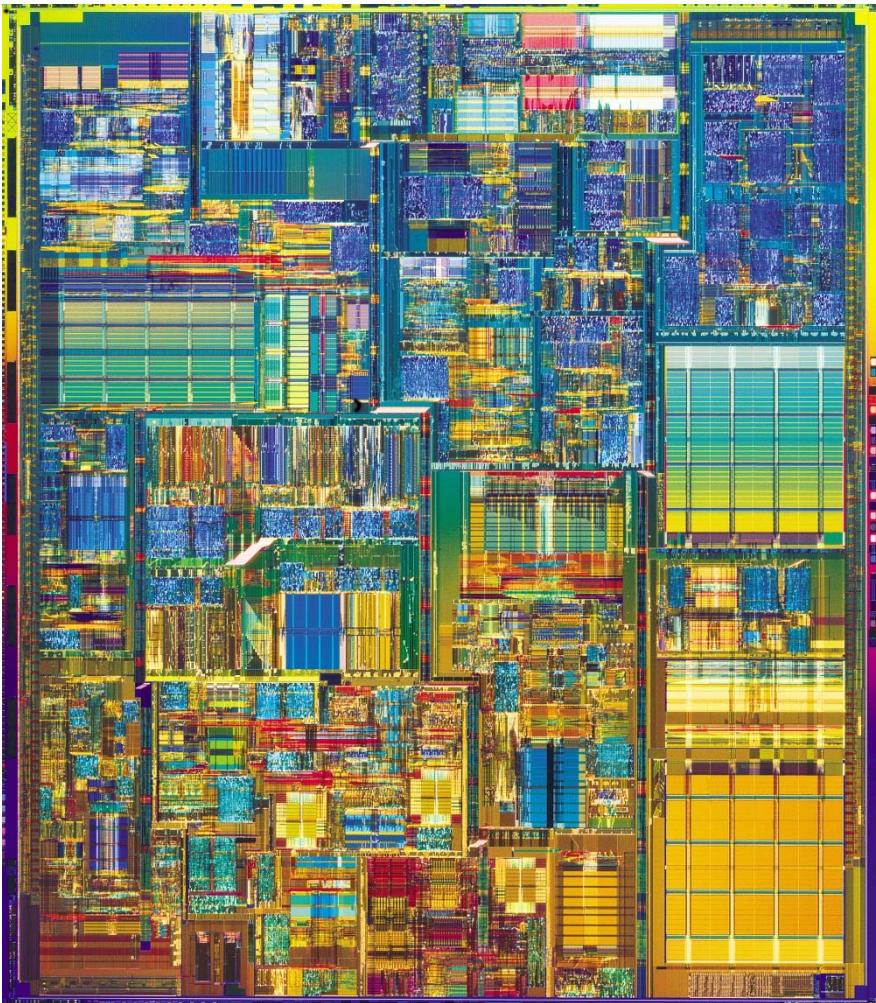


(P. Avouris)



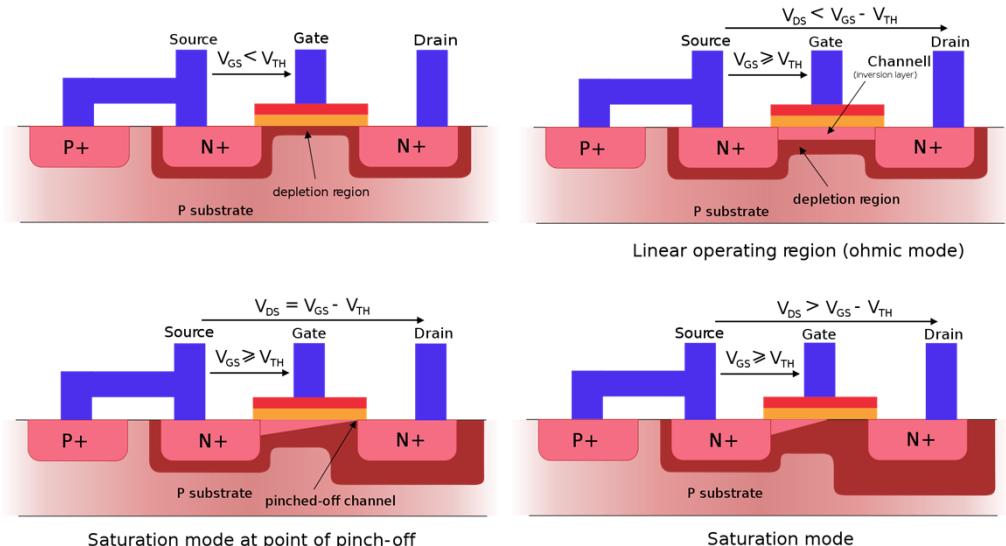
Today 300GHz !  
Tomorrow 500GHz ?

# MOS-FET transistors for digital applications

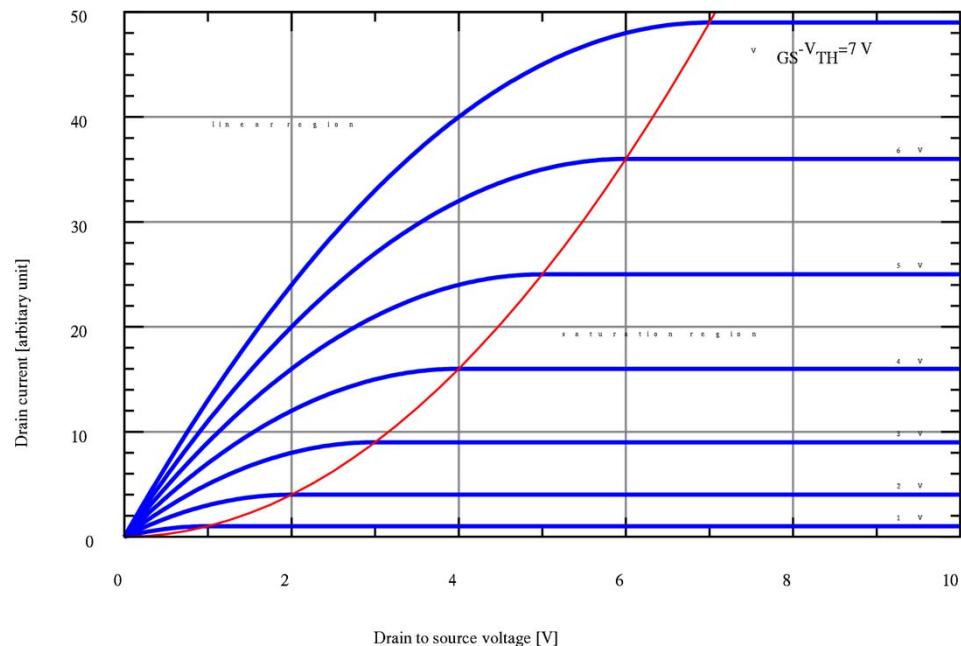


(Pentium 4, INTEL)

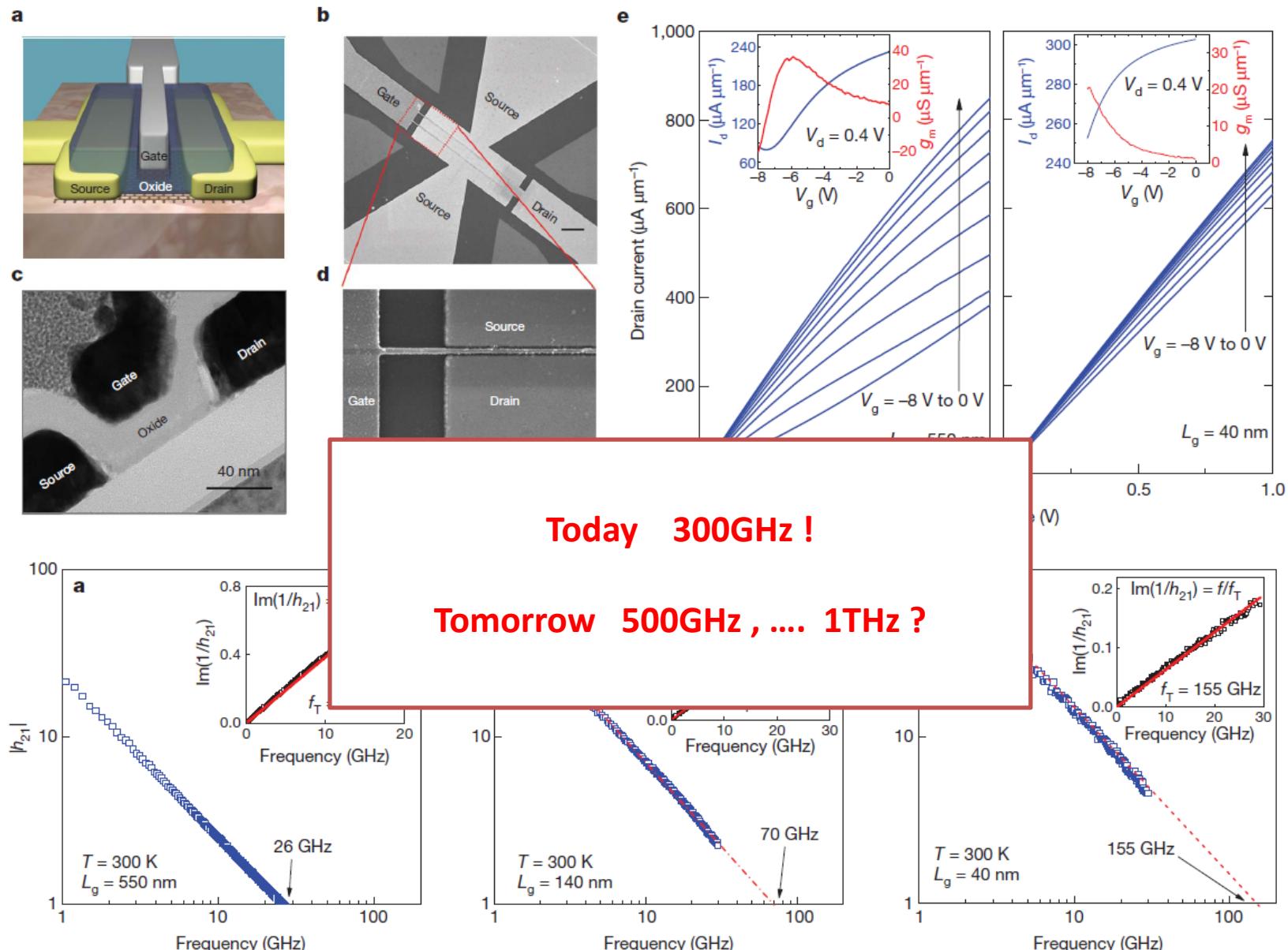
ER-Tremblay, 28/06/2012



(taken from wikipedia.org)



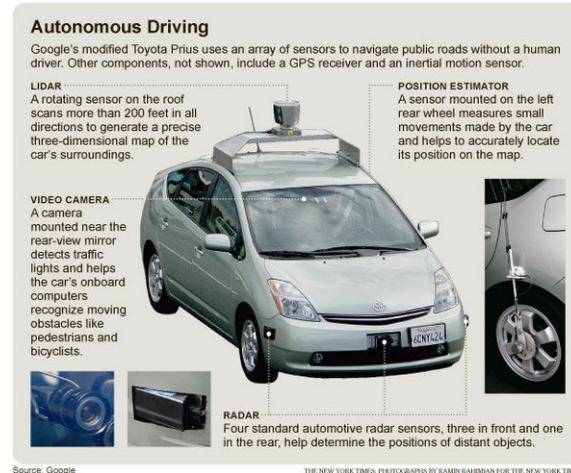
# Microwave transistors by IBM



# Applications of graphene transistors



*radars for aircrafts*



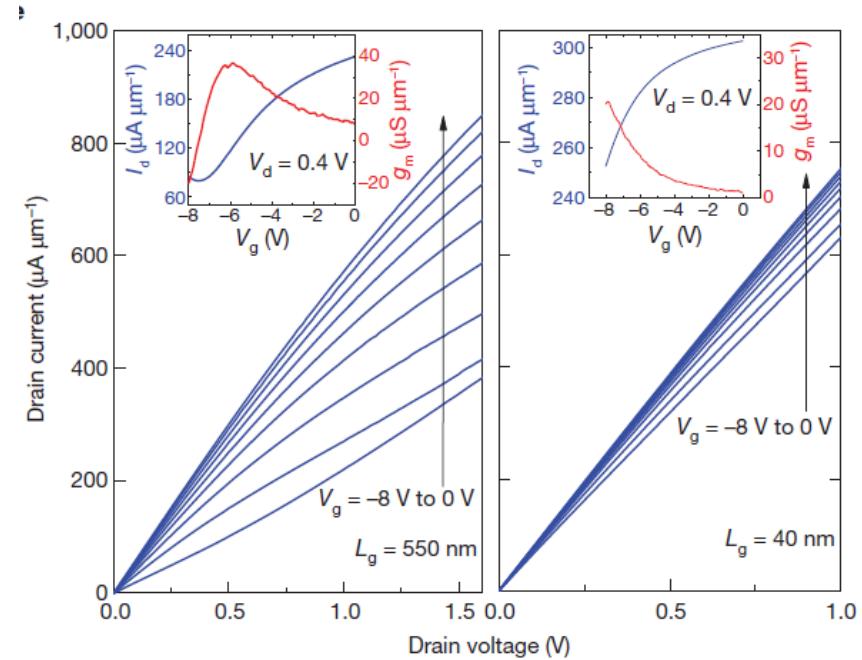
*radar for (Google) Car*



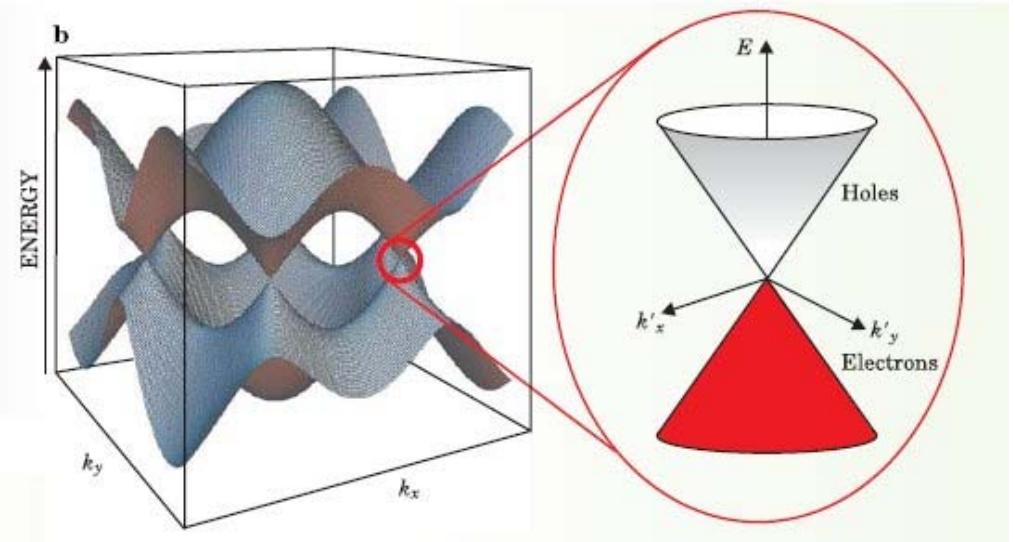
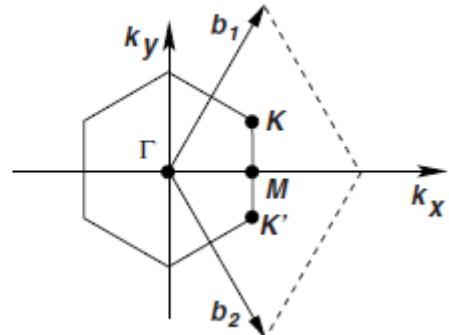
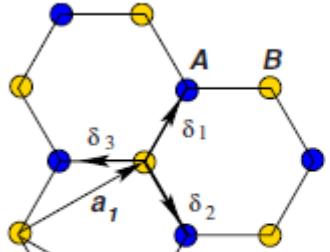
*THz imaging*



ER-Tremblay, 28/06/2012



- 1) Introduction to magic graphene
- 2) Transit frequency of microwave transistors
- 3) Diffusion probed in a field-effect capacitor
- 4) Acoustic phonons controls noise of resistors
- 5) New transistor architectures



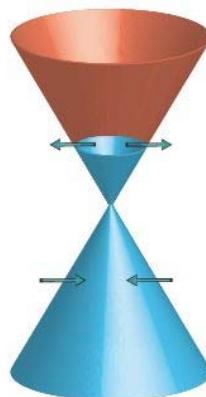
$$H = \hbar v_F \begin{pmatrix} 0 & q_x - iq_y \\ q_x + iq_y & 0 \end{pmatrix} = \hbar v_F \boldsymbol{\sigma} \cdot \mathbf{q}$$

avec  $q = K - k$  et  $\boldsymbol{\sigma}$  les matrices de Pauli

$$v_F = \frac{3}{2} t a = 10^6 \text{ m/s}$$

$$\Psi_{\pm K}(q) = \frac{e^{iq \cdot r}}{\sqrt{2}} \begin{pmatrix} 1 \\ \pm e^{i\theta_q} \end{pmatrix} \text{ avec } \theta_q = \tan^{-1} \frac{q_x}{q_y}$$

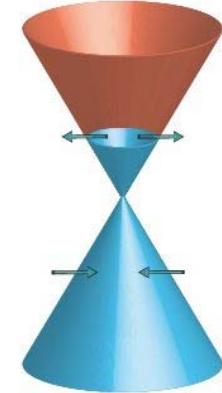
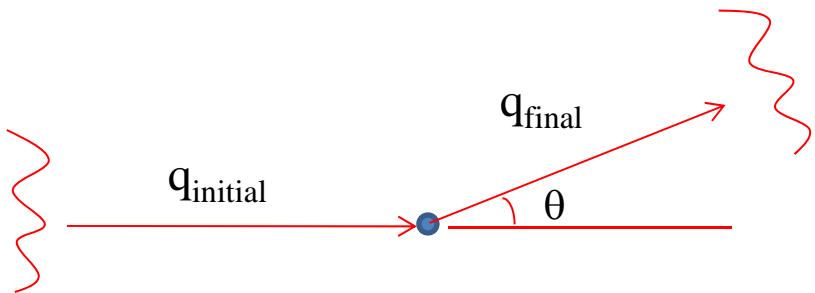
(P.R. Wallace, PRB 1947)



$$H = -t \sum_{i,j,\sigma} (a_i^* b_j + H.c.)$$

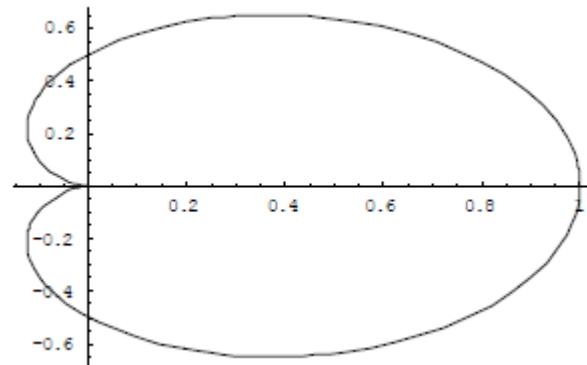
$t \approx 2,8 \text{ eV}$        $a \approx 0,14 \text{ nm}$

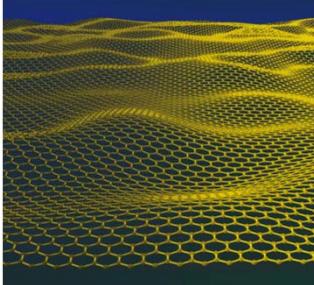
# Pseudo-spin suppresses back scattering



$$\tau^{-1} \propto \int d\theta (1 - \cos \theta) (\mathbf{1} + \cos \theta) |V(q)|^2$$

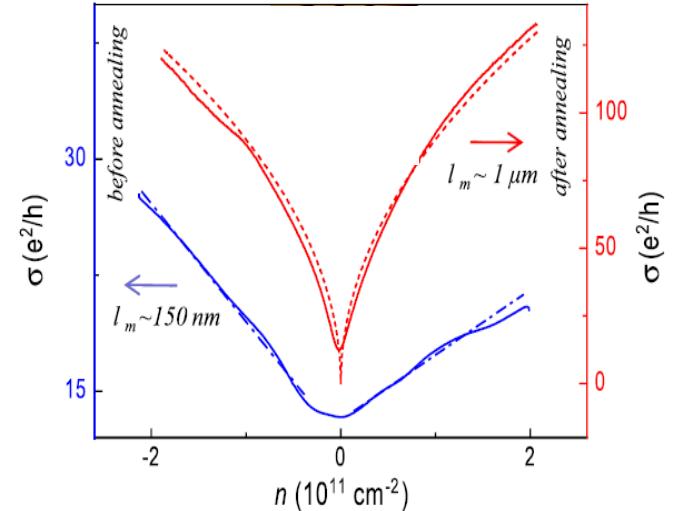
*Whence the large mobility at low temperature !*



scalar	gauge-field	Dirac-mass
$H_K = \hbar v_F \sigma \cdot q$	$+ V(q) \hat{I}$	$+ \alpha \sigma \cdot U + \delta m^* \sigma_z$
$\hat{I} = \begin{pmatrix} 1 & 0 \\ 0 & 1 \end{pmatrix}$		$\sigma_z = \begin{pmatrix} 1 & 0 \\ 0 & -1 \end{pmatrix}$
		

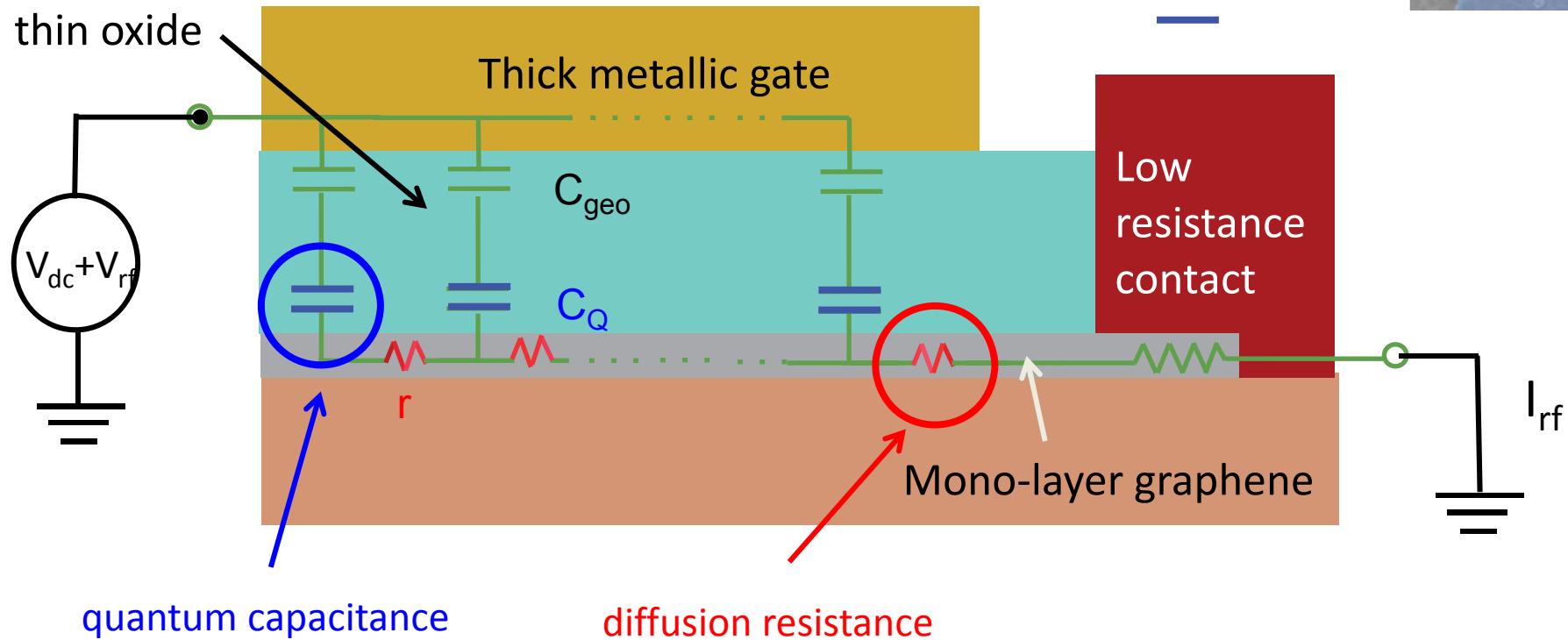
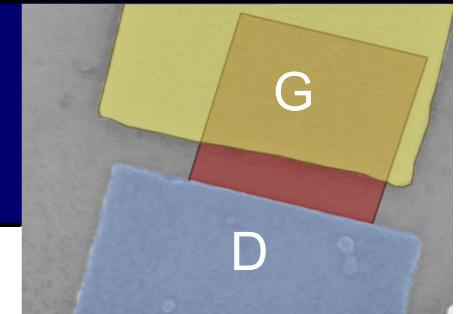
- scalar disorder ( $\hat{I}$ -term), short range : adsorbates, void, etc...)
- scalar disorder ( $\hat{I}$ -term), long range : no screening of charged impurities
- gauge field disorder : static distortions like ripples, etc...
- Dirac mass disorder : local lifting of sublattice degeneracy

*Castro-Neto et al. RMP 2009,  
 Peres et al. RMP 2010,  
 Das Sarma et al. RMP 2011,  
 etc.....*



mechanisms	scattering time	conductivity
local impurity	$\tau \sim 1/k_F$	$\sigma \sim \text{Const}$
local impurity	$\tau \sim \ln k_F/k_F$	$\sigma \sim \ln n_c$
random Dirac-mass	$\tau \sim \text{Const}$	$\sigma \sim \sqrt{n_c}$
charged impurity	$\tau \sim k_F$	$\sigma \sim n_c$
resonant scattering	$\tau \sim k_F \ln^2(k_F)$	$\sigma \sim n_c \ln^2 n_c$
ripples	$\tau \sim k_F^{(2H-1)}$	$\sigma \sim n_c^H$
acoustic phonons	$\tau \sim k_F^2$	$\sigma \sim n_c^{3/2}$

# A graphene capacitor



# Electronic compressibility comes as a quantum capacitance

$$\Delta\mu_L = e\Delta V + \Delta\mu_L$$

$$= e\Delta V + \frac{1}{e} \frac{\partial\mu}{\partial n} \Delta q$$

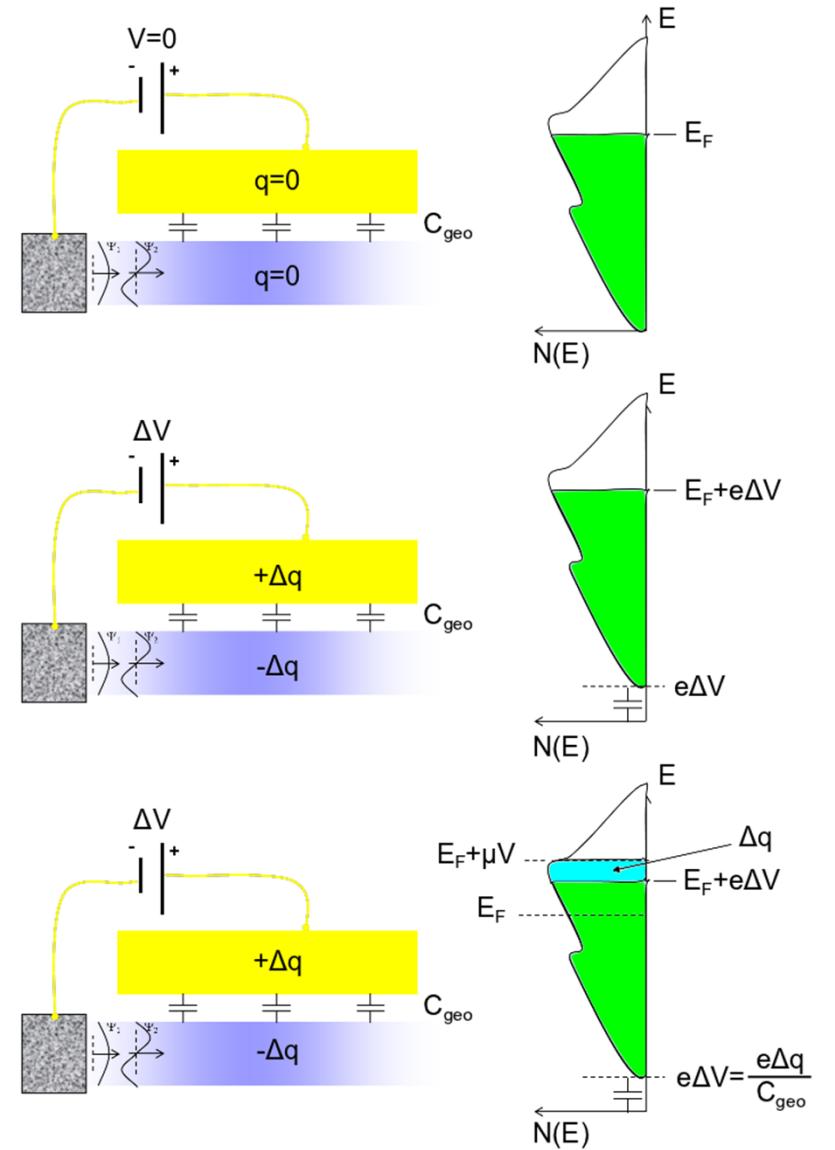
$$\frac{e\Delta q}{C_\mu} = \frac{e}{C_{géo}} \Delta q + \frac{1}{e\chi} \Delta q$$

$$\frac{1}{C_\mu} = \frac{1}{C_{géo}} + \frac{1}{e^2 \chi}$$

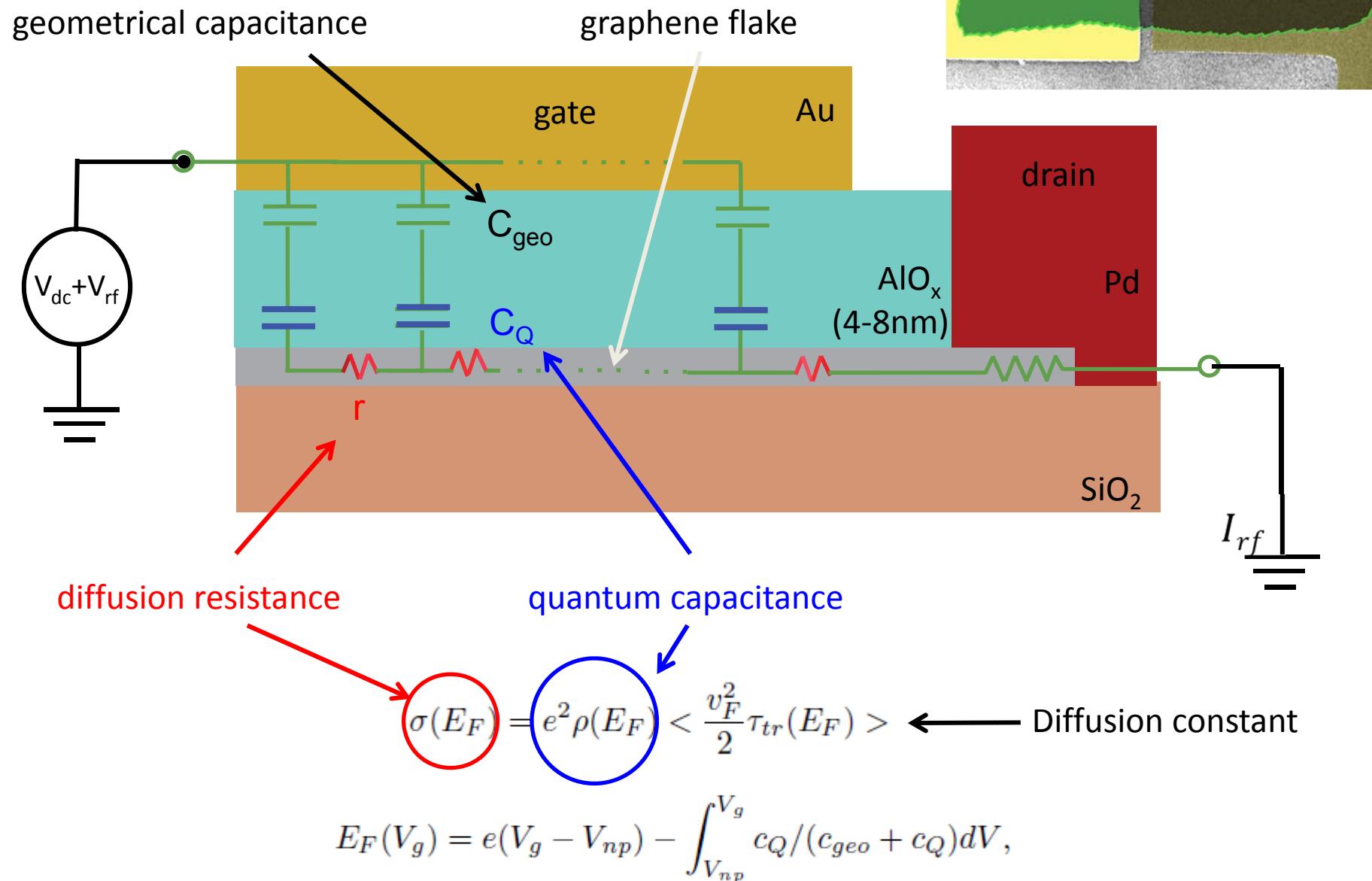
$$C_Q = e^2 \chi \rightarrow e^2 \rho(E_F) \quad (T \rightarrow 0)$$

graphene :

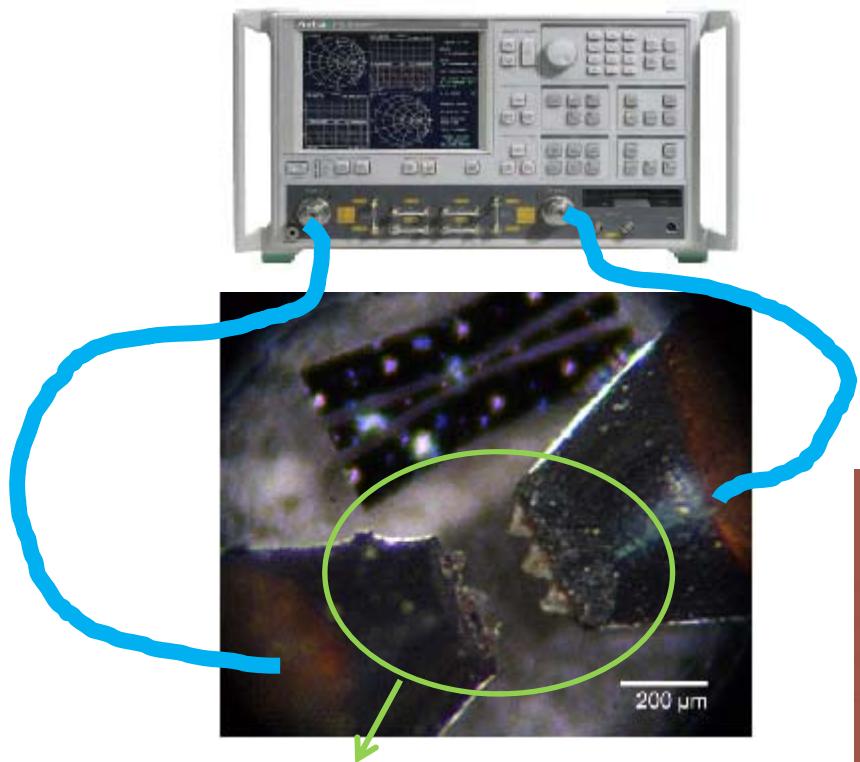
$$C_Q = \frac{2e^2 k_B T}{\pi(\hbar v_F)^2} \ln \left[ 2 + 2 \cosh \left( \frac{E_F}{k_B T} \right) \right] \rightarrow \frac{4e^2 E_F}{2\pi(\hbar v_F)^2} \quad (T \rightarrow 0)$$



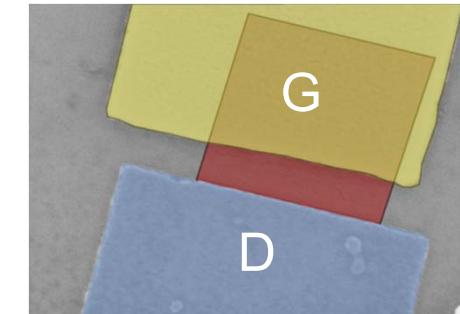
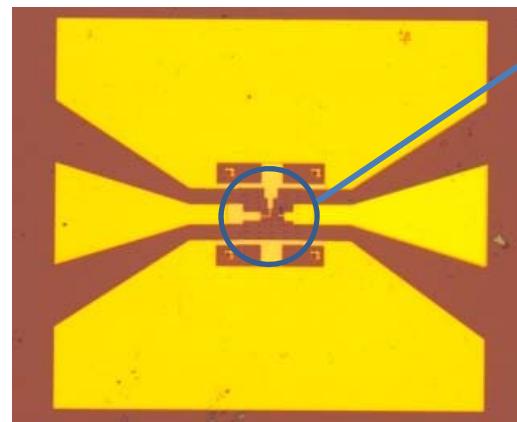
# Scattering time as function of energy



# Our graphene RF devices

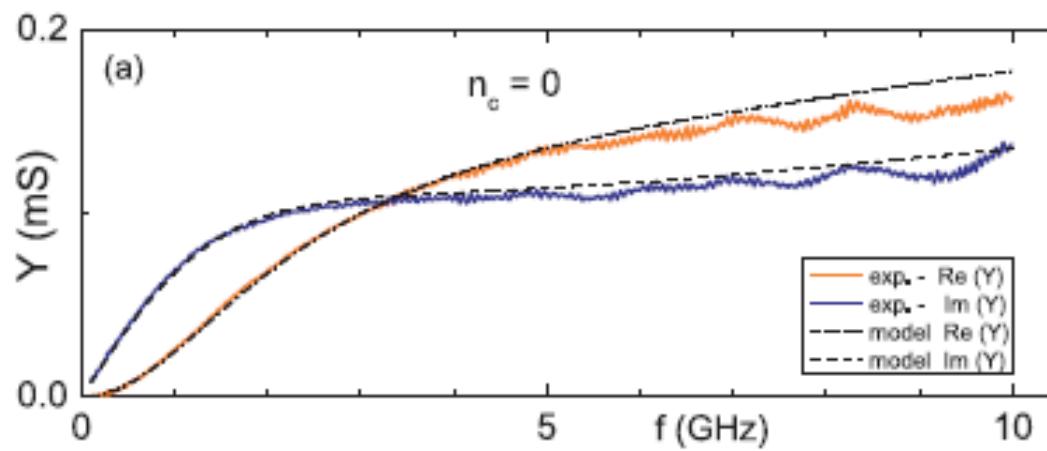
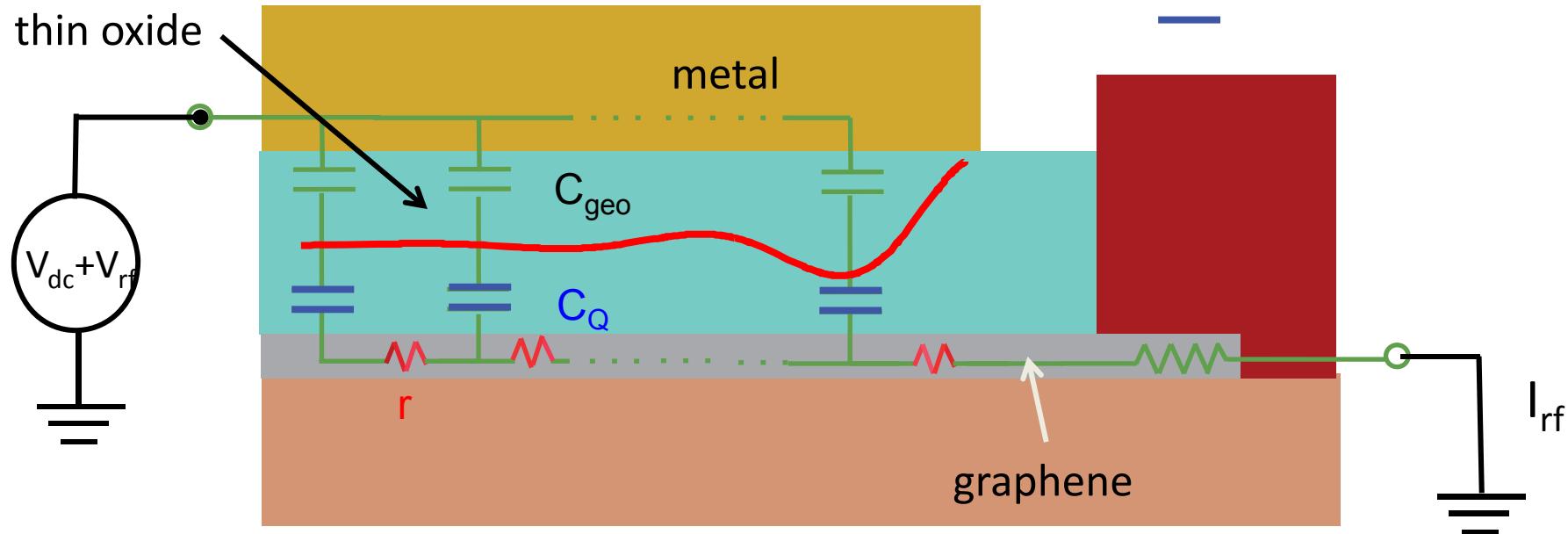


20GHz capacitor (admittance)



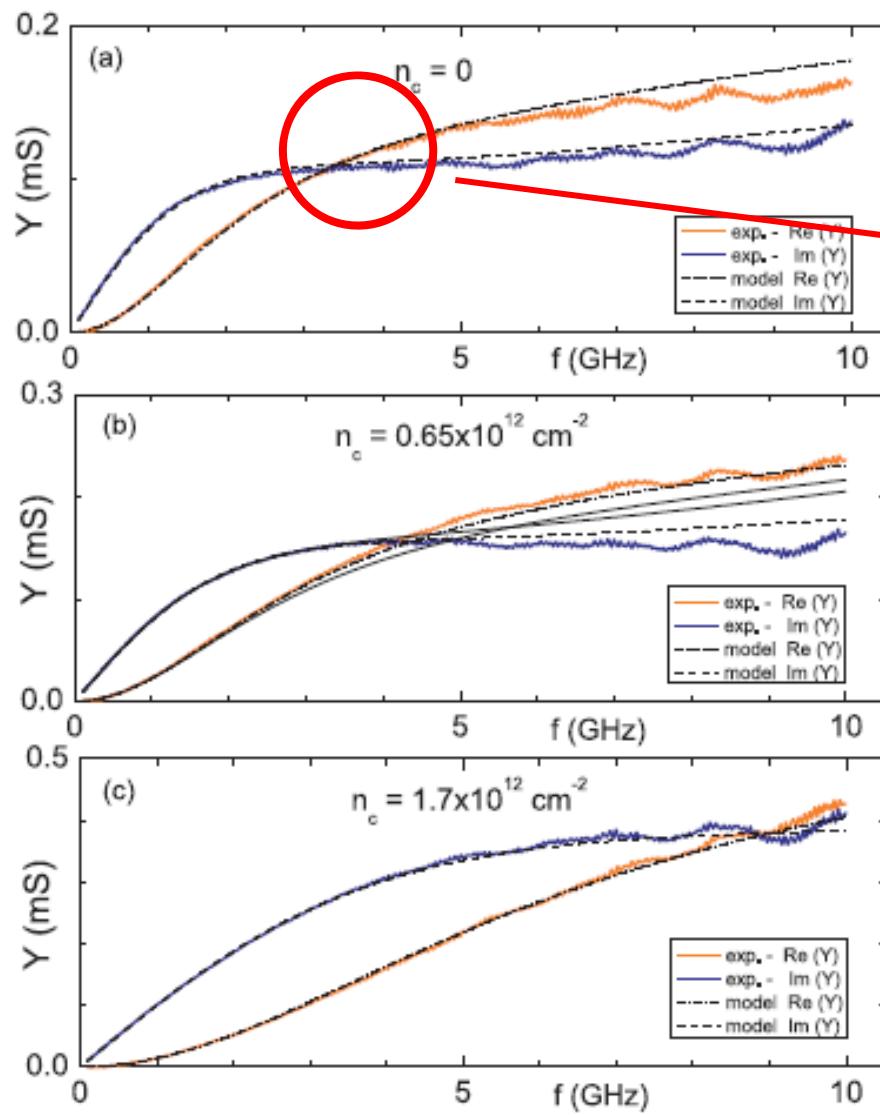
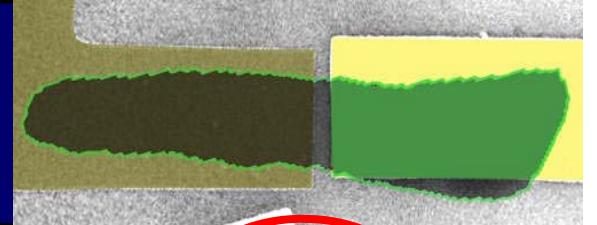
*E. Pallecchi et al, PRB 83 (2011)*

Wave guide (CPW)

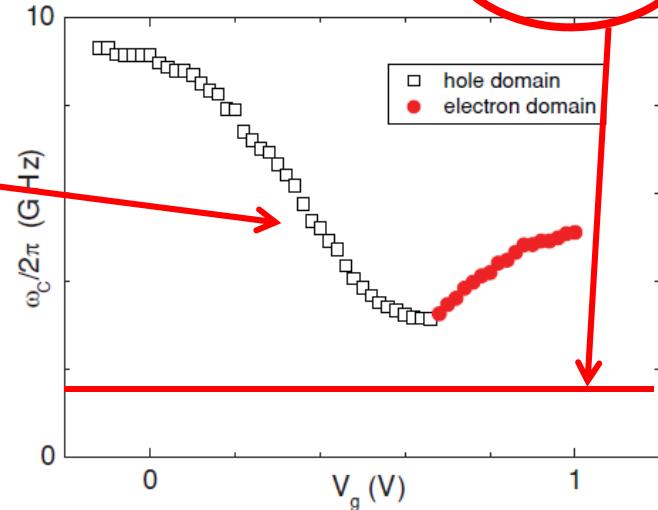


$$Y = j\omega \omega_c \times \frac{\tanh[(1+j)L/\sqrt{rc\omega}]}{(1+j)L/\sqrt{rc\omega}}$$

## Cutt-off frequency

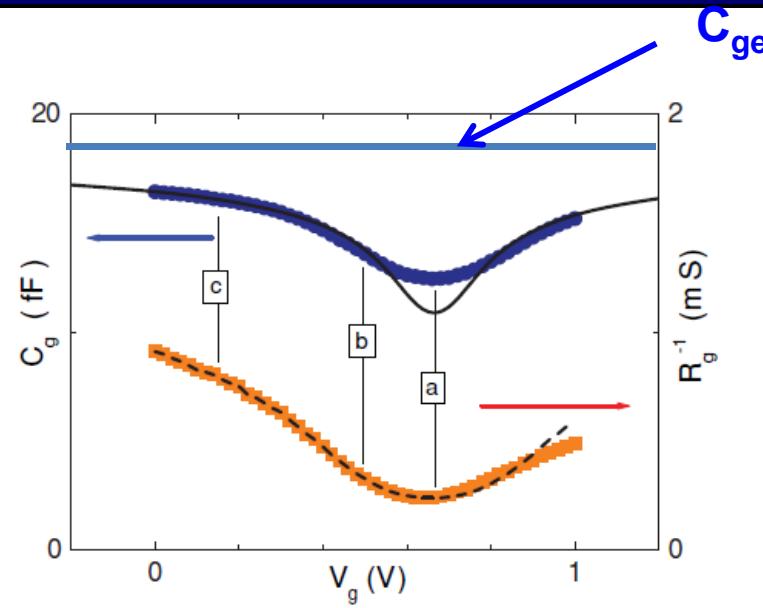
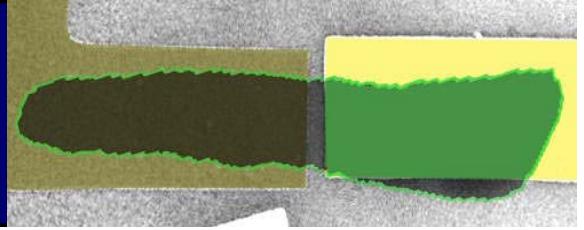


$$\omega_c = \frac{\pi^2}{2} \sigma / c_{\text{geo}} L^2 - \frac{\pi^2}{2} D / L^2.$$



**Thouless energy protects  
graphene device dynamics !**

# Gate voltage dependence



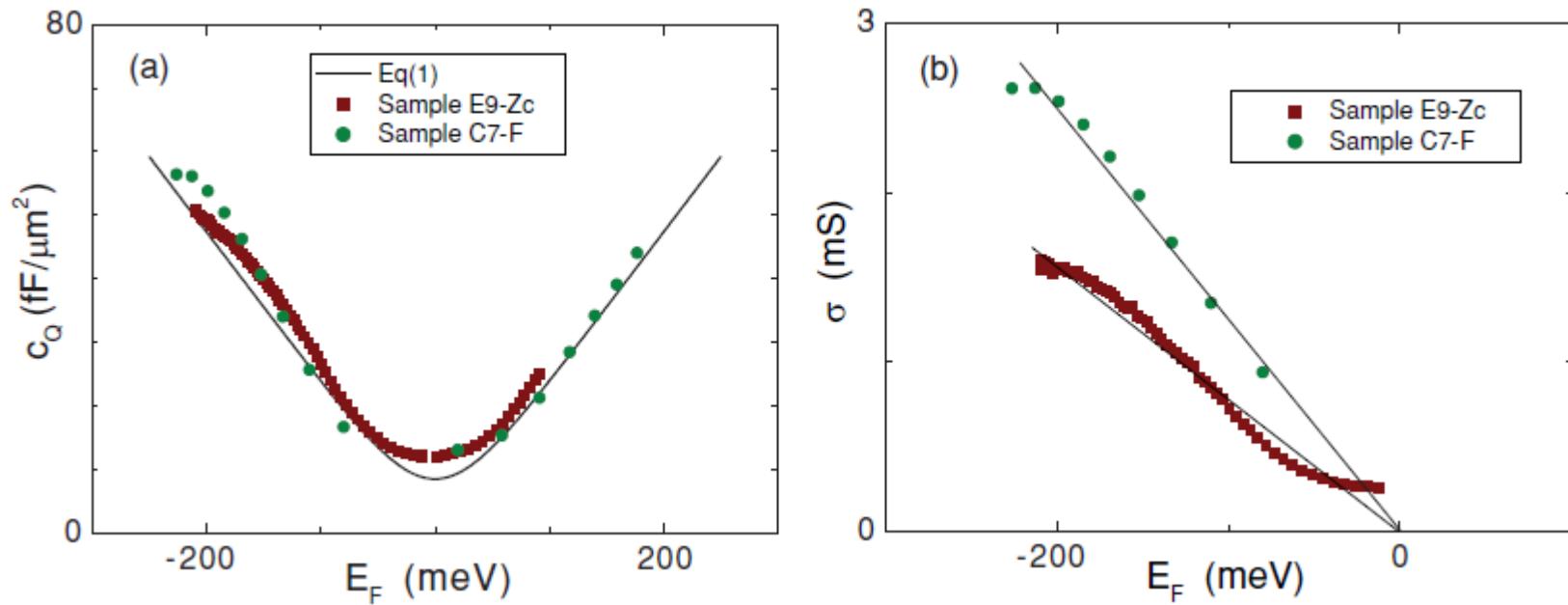
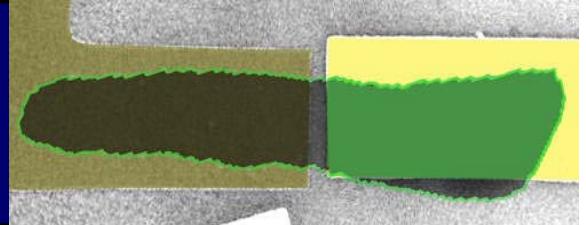
$$\sigma(E_F) = e^2 \rho(E_F) < \frac{v_F^2}{2} \tau_{tr}(E_F) >$$

$$E_F(V_g) = e(V_g - V_{np}) - \int_{V_{np}}^{V_g} c_Q / (c_{geo} + c_Q) dV,$$

<i>mechanisms</i>	<i>scattering time</i>	<i>conductivity</i>
local impurity	$\tau \sim 1/k_F$	$\sigma \sim Const$
local impurity	$\tau \sim \ln k_F/k_F$	$\sigma \sim \ln n_c$
random Dirac-mass	$\tau \sim Const$	$\sigma \sim \sqrt{n_c}$
charged impurity	$\tau \sim k_F$	$\sigma \sim n_c$
resonant scattering	$\tau \sim k_F \ln^2(k_F)$	$\sigma \sim n_c \ln^2 n_c$
ripples	$\tau \sim k_F^{(2H-1)}$	$\sigma \sim n_c^H$
acoustic phonons	$\tau \sim k_F^2$	$\sigma \sim n_c^{3/2}$

$D(E_F) = \text{Const}$  (Dirac-mass disorder)

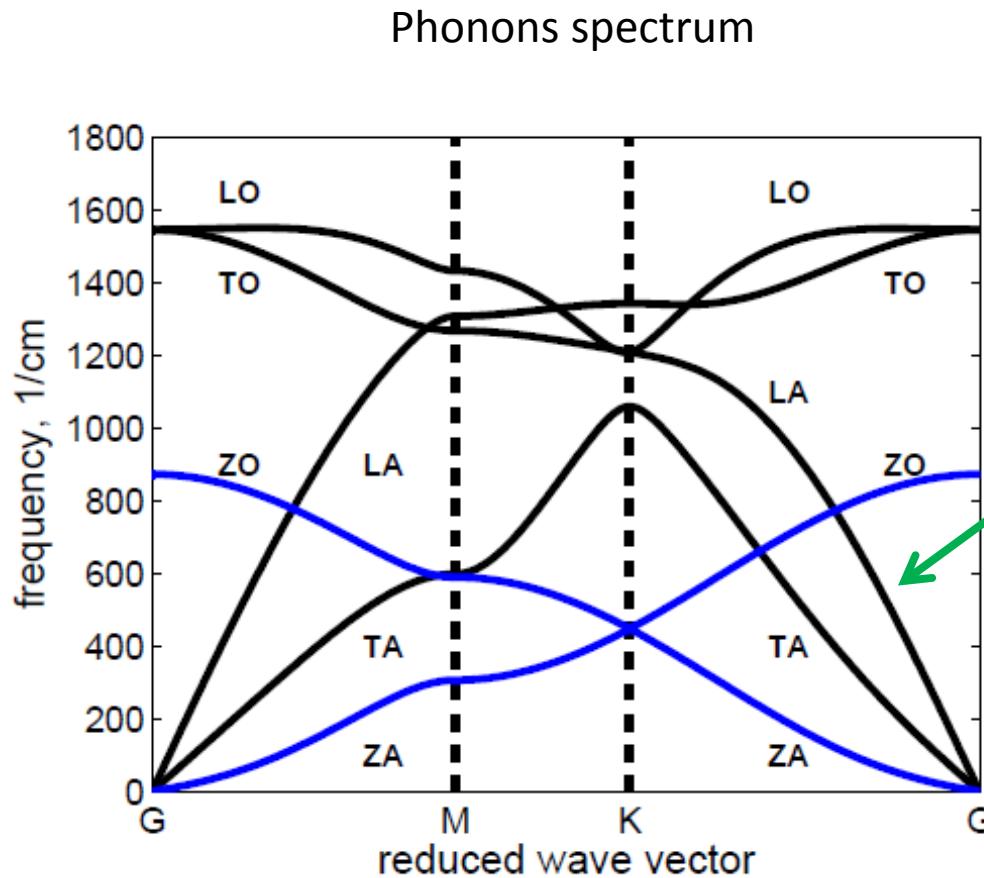
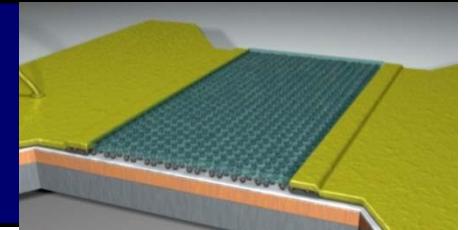
## Fermi energy dependence



$$E_F(V_g) = e(V_g - V_{np}) - \int_{V_{np}}^{V_g} c_Q / (c_{geo} + c_Q) dV,$$

- 1) Introduction to magic graphene
- 2) Transit frequency of microwave transistors
- 3) Diffusion probed in a field-effect capacitor
- 4) Acoustic phonons controls noise of resistors
- 5) New transistor architectures

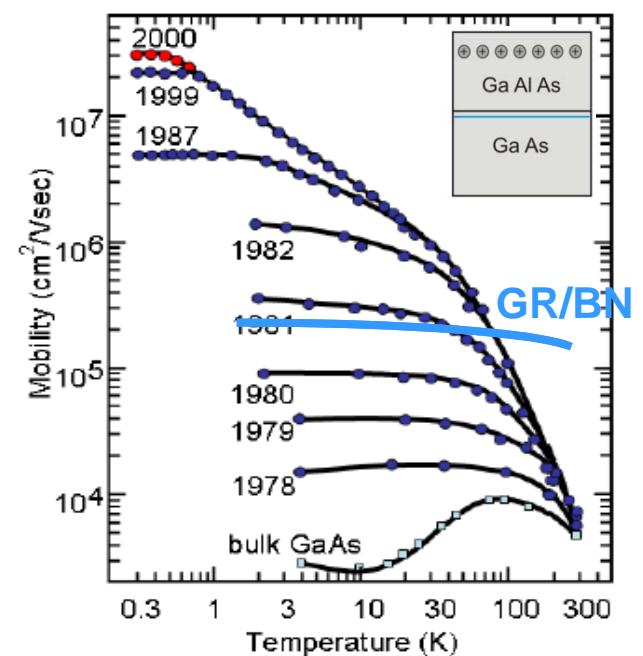
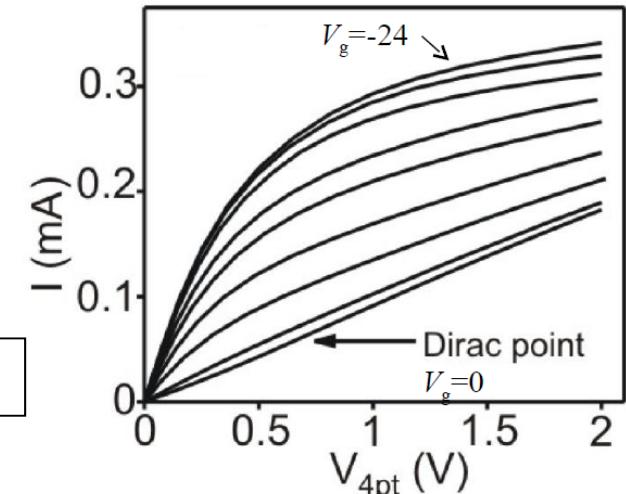
# Electron-phonon in graphene



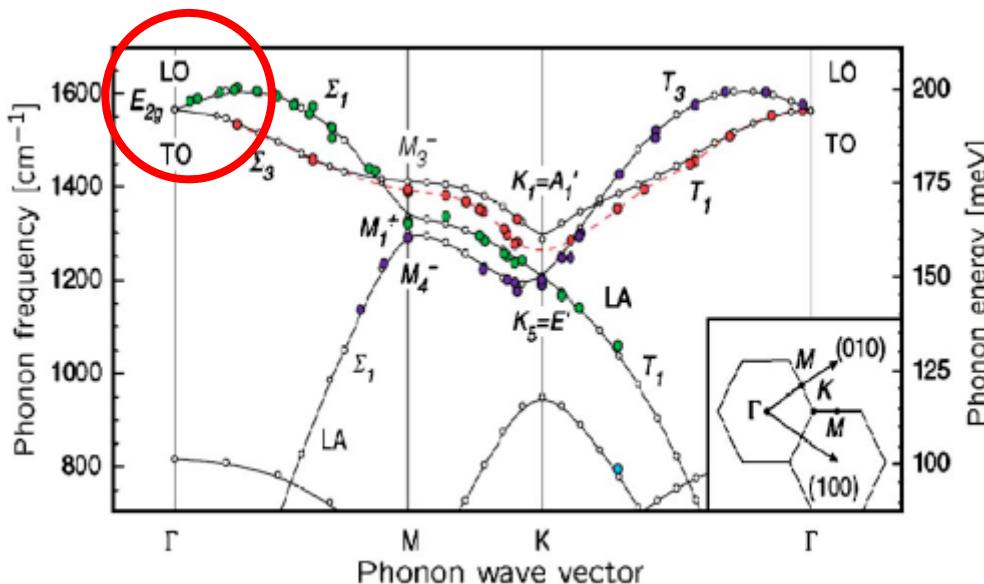
optical (strong)

$c = 20\,000 \text{ m/s}!$

acoustic (weak)

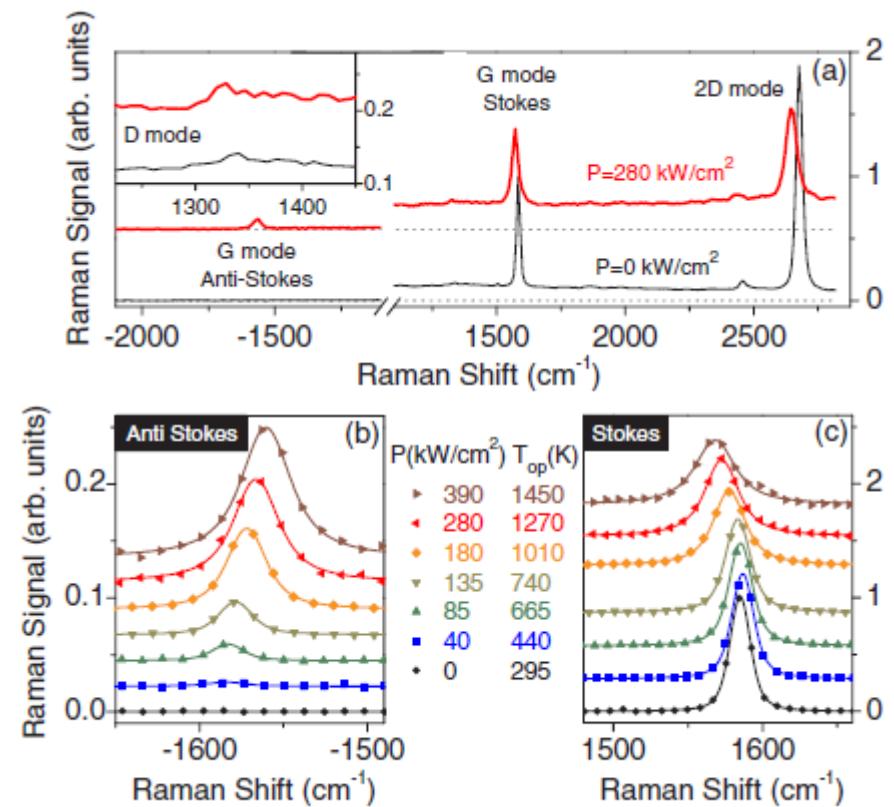


- Large O-Phonon energy
- Weak A-Phonon coupling

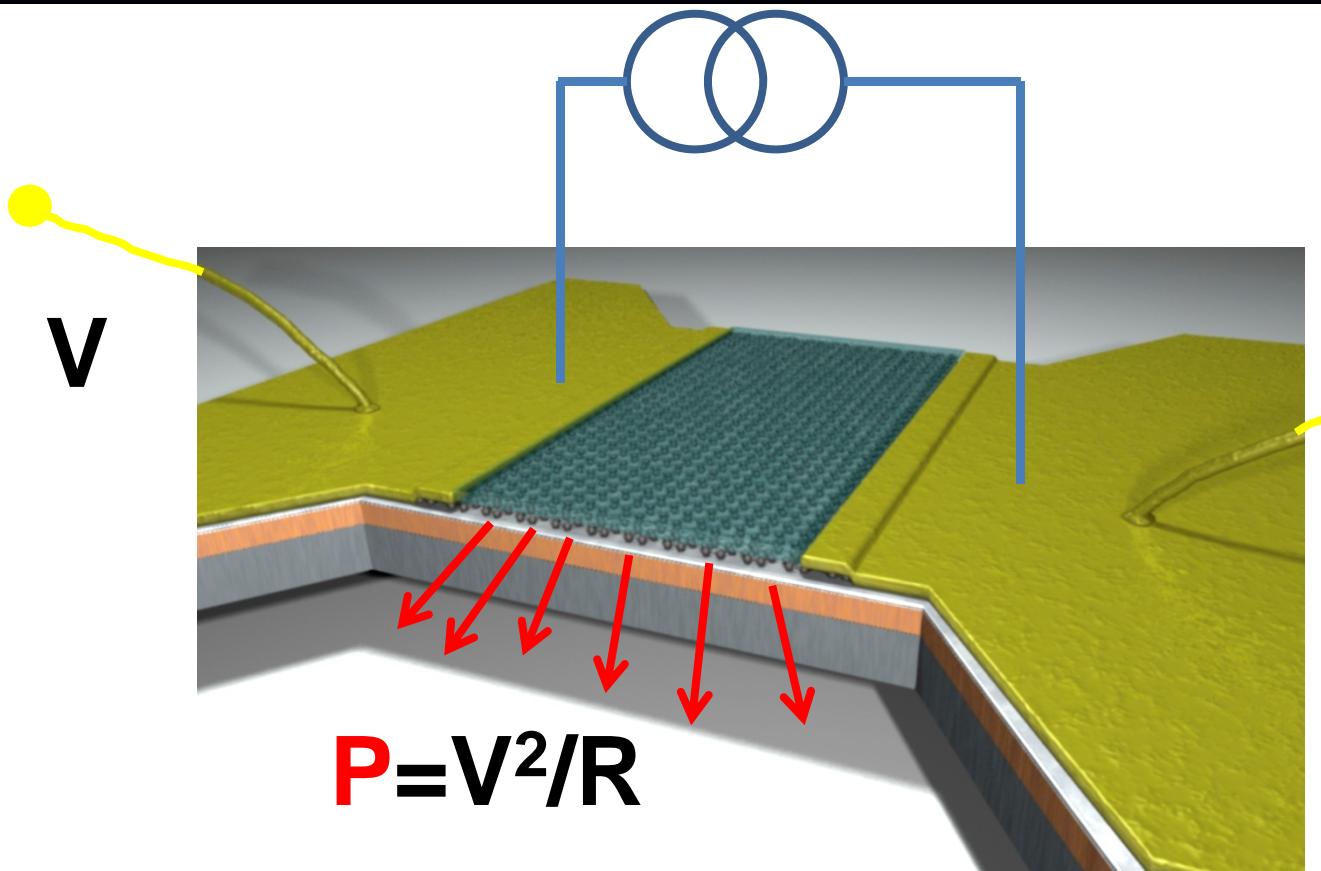


OP interactions (Kohn anomalies)

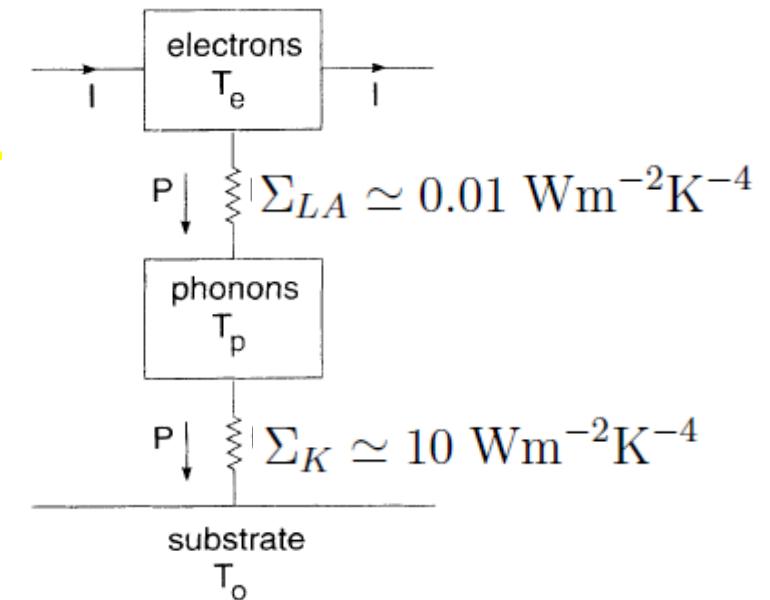
## OP/AP populations

*(Berciaud, Han, Mak, Brus, Kim, Heinz, PRL2010)*

# Hot -electron experiment



$$S_I = 4k_B T_e / R$$



$$V \cdot I = Volume \times \Sigma(T_e^5 - T_{ph}^5) \quad (3D) \quad (\text{metals})$$

$$V \cdot I = Area \times \Sigma(T_e^4 - T_{ph}^4) \quad (2D) \quad (\text{graphene ?})$$

$$V \cdot I = Length \times \Sigma(T_e^3 - T_{ph}^3) \quad (1D) \quad (\text{nanotubes})$$

# Hot -electron experiment

**cooling power**

(metals)

$$Q = Volume \times \Sigma \left( T_e^5 - T_{ph}^5 \right) \quad (3D)$$

$$Q = Area \times \Sigma \left( T_e^4 - T_{ph}^4 \right) \quad (2D)$$

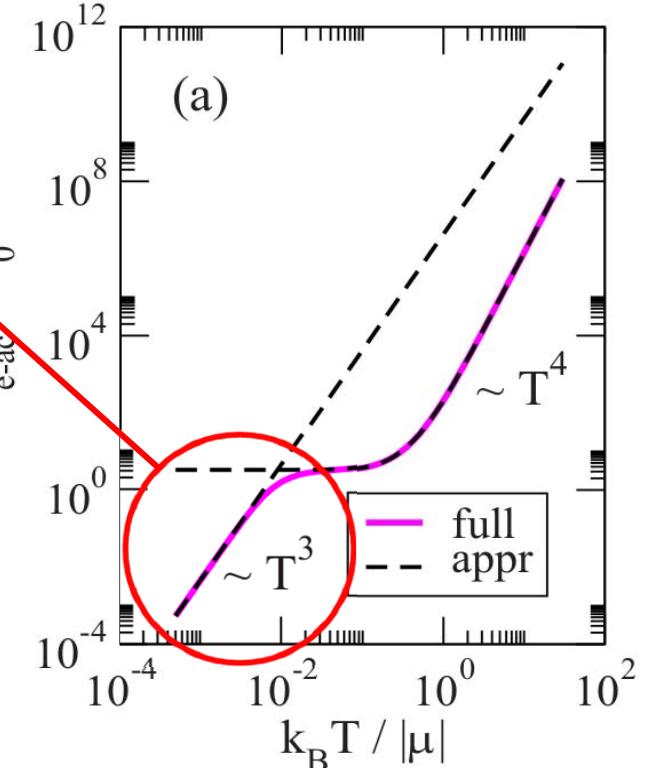
$$Q = Length \times \Sigma \left( T_e^3 - T_{ph}^3 \right) \quad (1D)$$

(1D nanotubes, Wu et al. APL 2011,

$$\Sigma_{LA} = \frac{\pi^2 D^2 k_B^4}{15\rho\hbar^5 v_F^3 c^3} \times |E_F|$$

**heat sink**

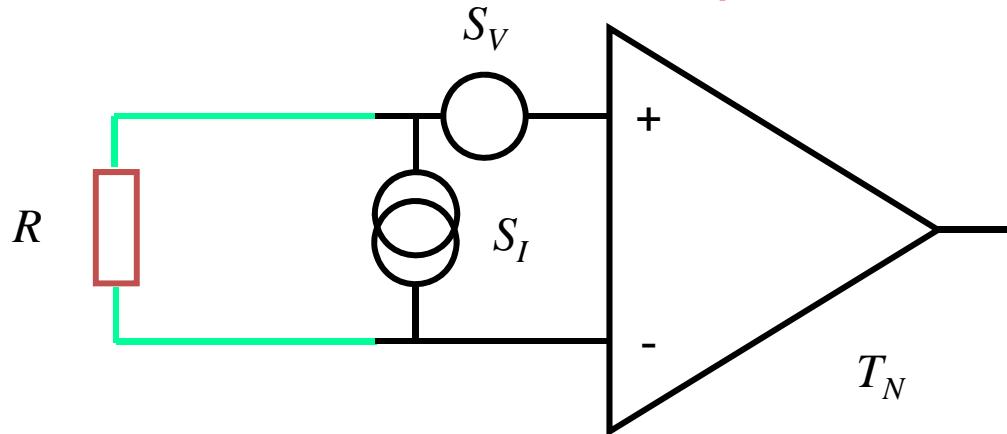
$$G = 4\Sigma T^3 \Delta T$$



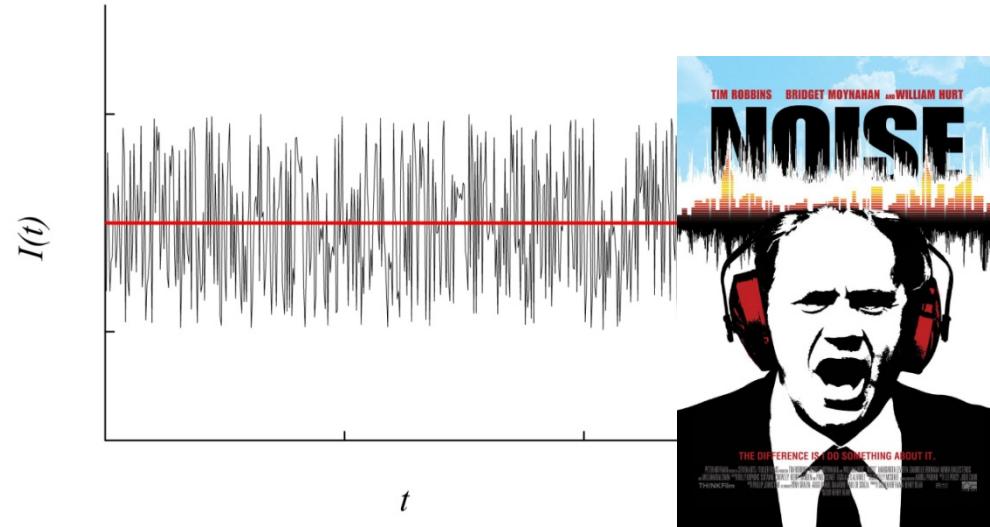
Theory : Viljas et al. PRB 2010

# What is electrical noise ?

## Noise of an amplifier



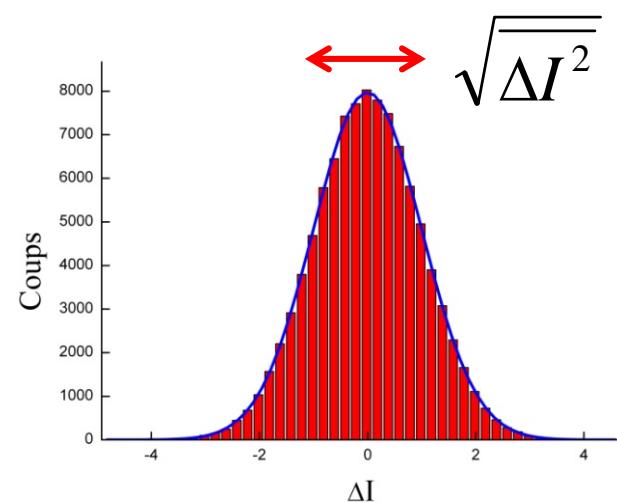
$$S_V^{in} = S_V + R^2 S_I$$



## Statistical distribution

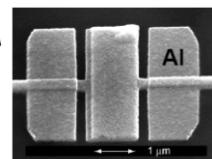
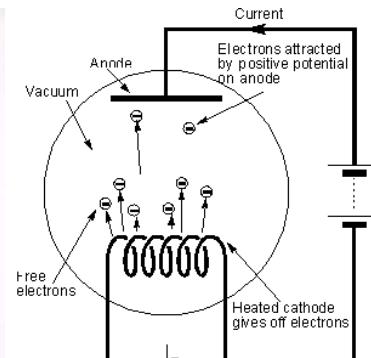
Fluctuations :  $\Delta I(t) = I(t) - \overline{I(t)}$

Noise spectrum :  $\overline{\Delta I^2(t)} = \int S_I(\nu) \Delta\nu$



# Physics of noise

Shot-noise

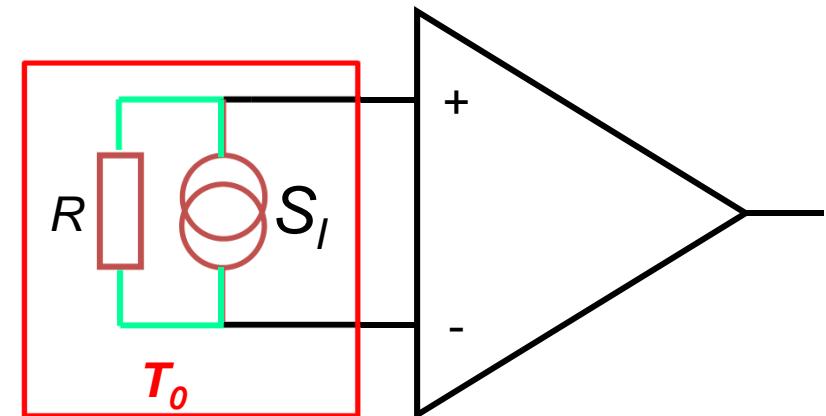


*W. Schottky*

$$S_I = 2e\bar{I}$$

and/or

Thermal noise



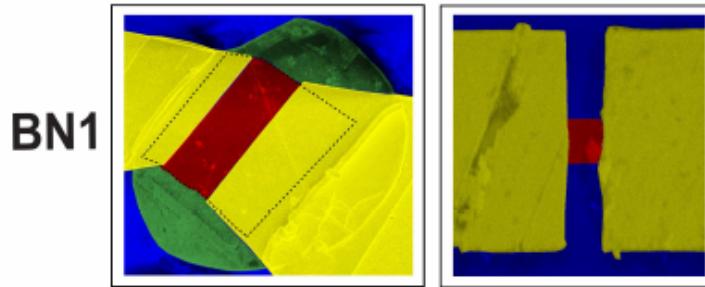
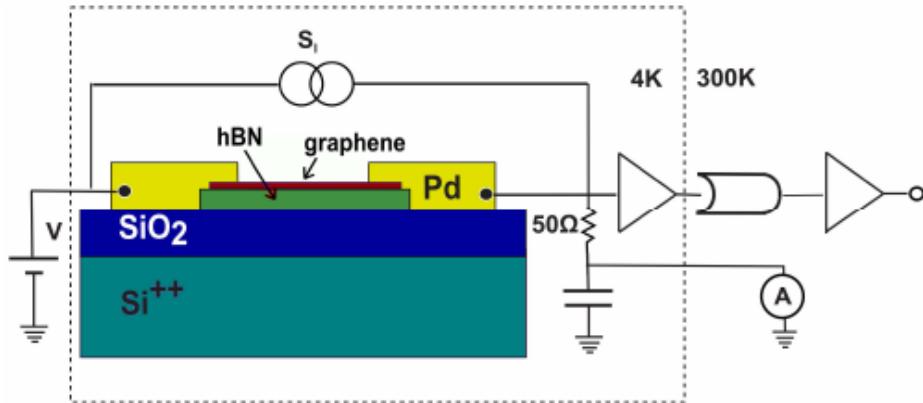
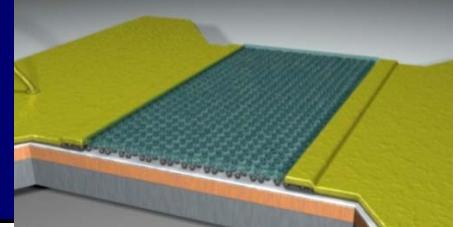
*J.B. Johnson*



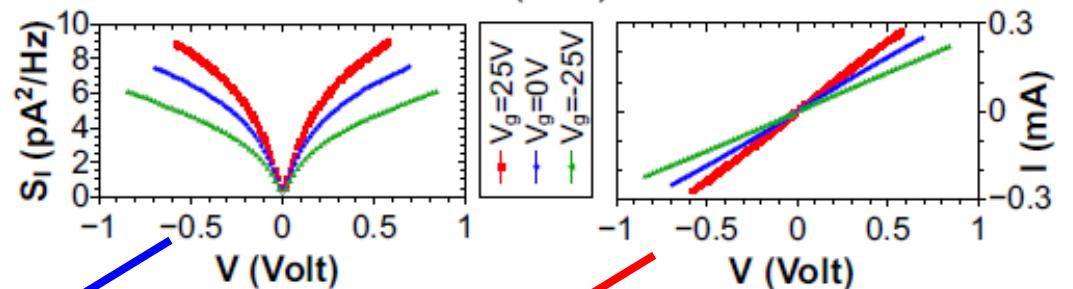
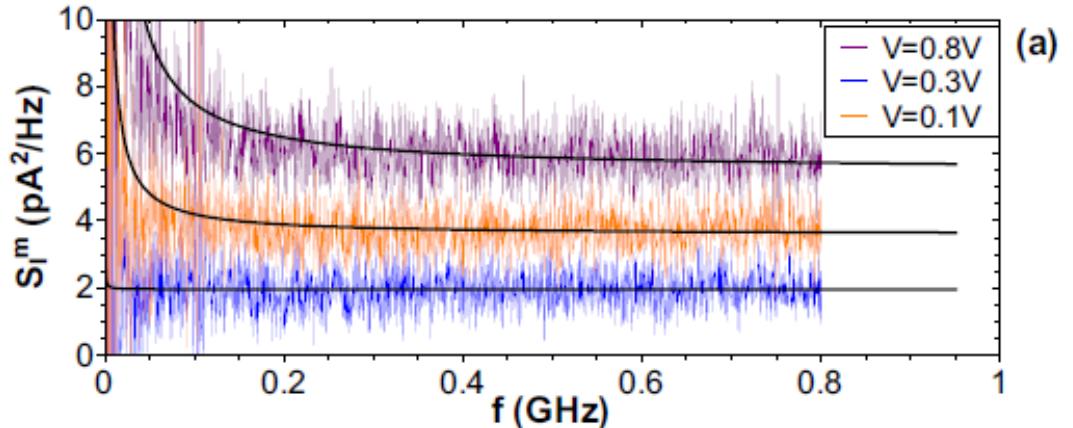
*H. Nyquist*

$$S_I = 4k_B T_0 / R$$

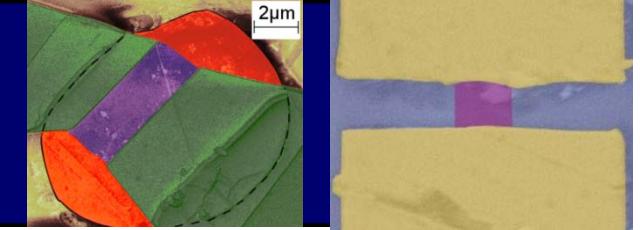
## Noise thermometry



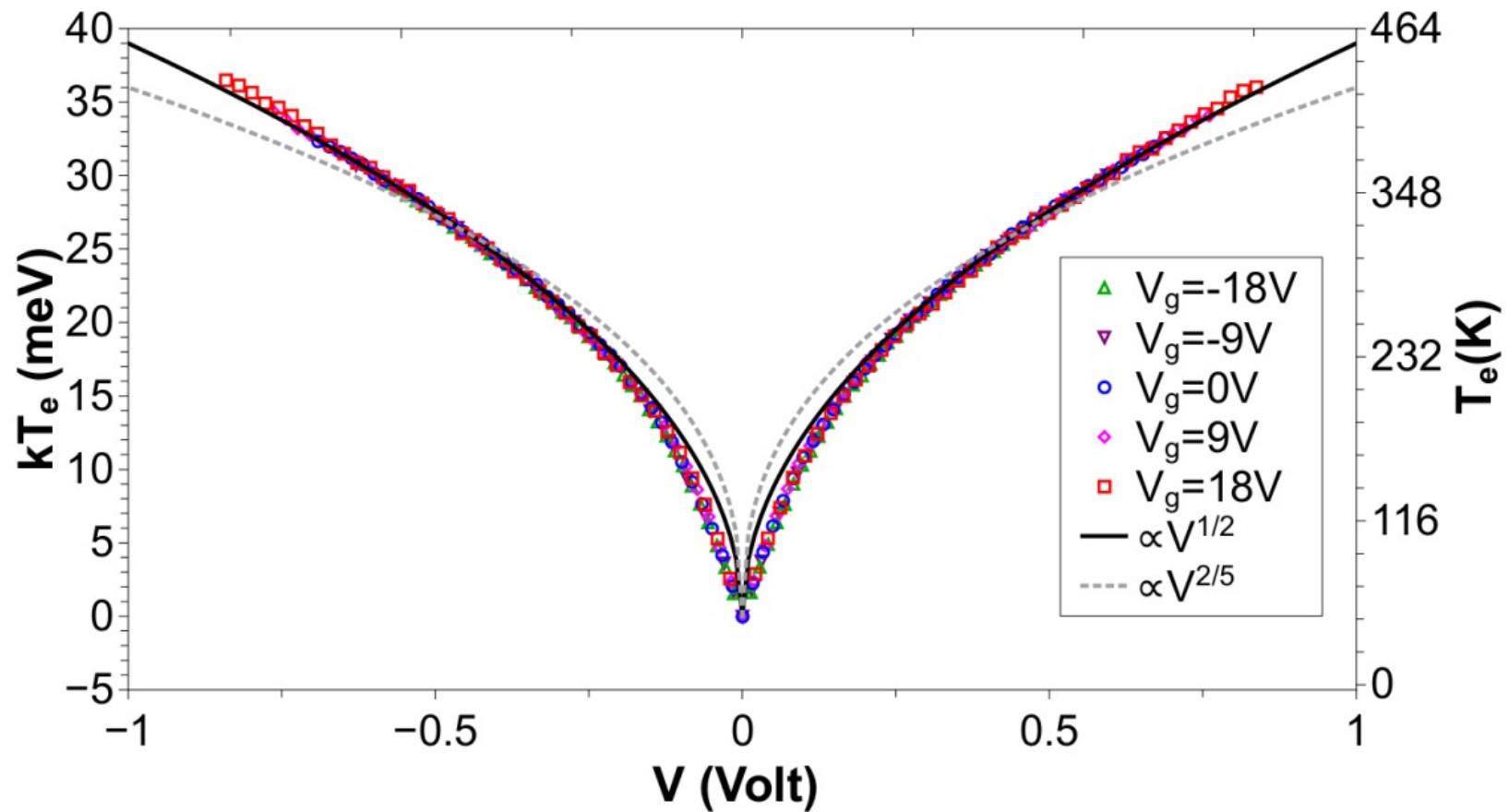
CVD1



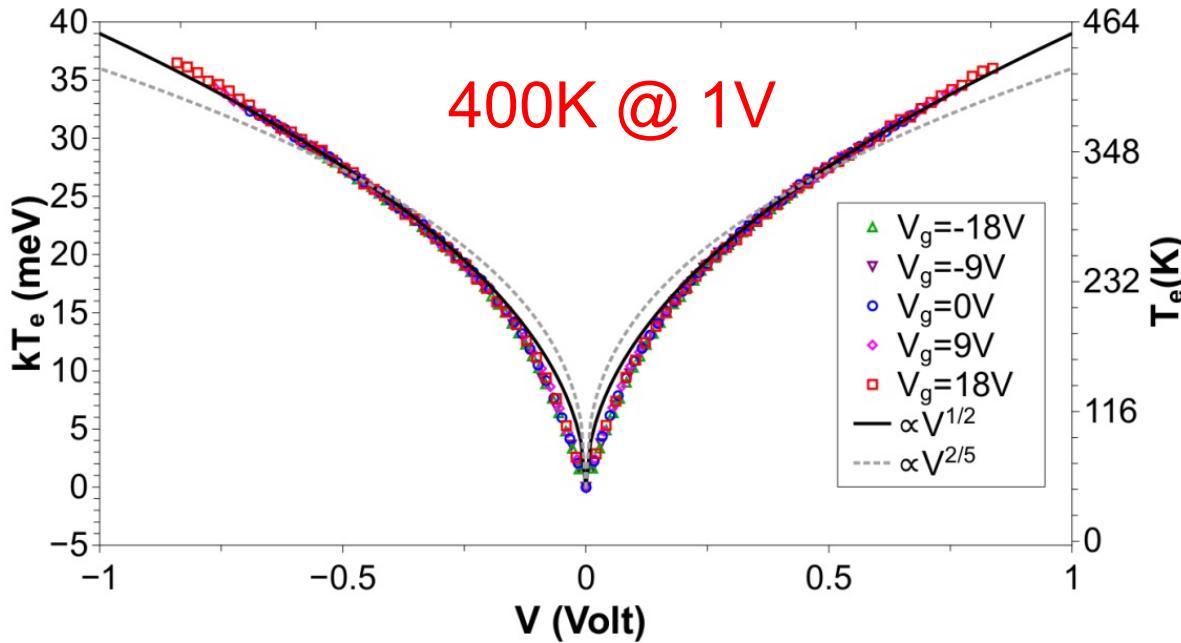
$$S_I(V_g, V_{ds}) = 4 G(V_g, V_{ds}) k_B [T_N + \langle T_e \rangle_x(V_g, V_{ds})]$$



$T \sim P^{1/4} \sim V^{1/2}$  !

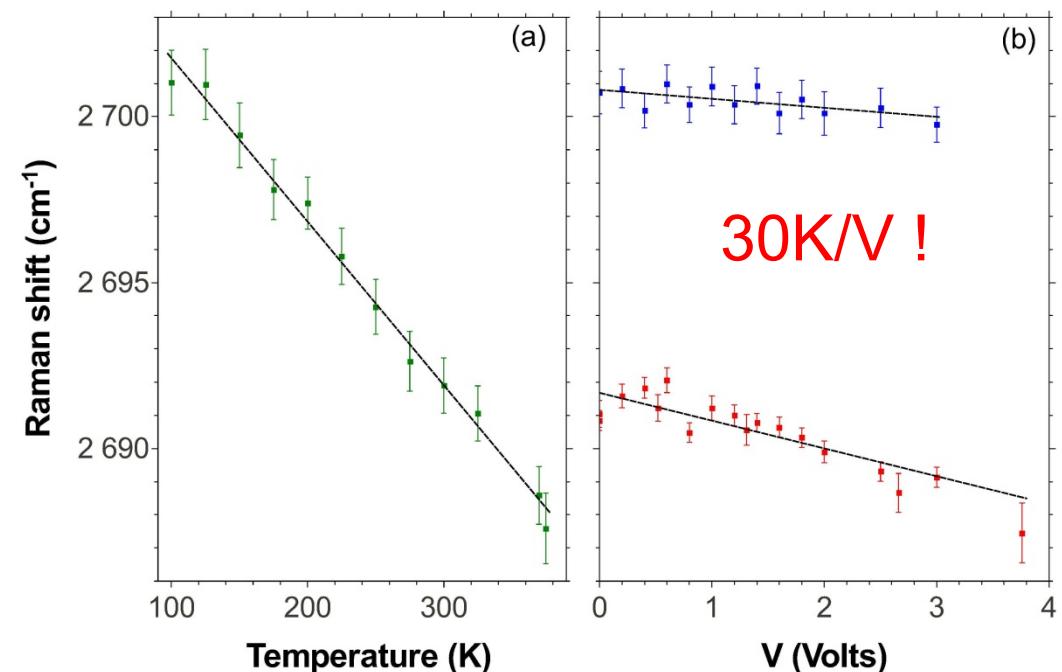
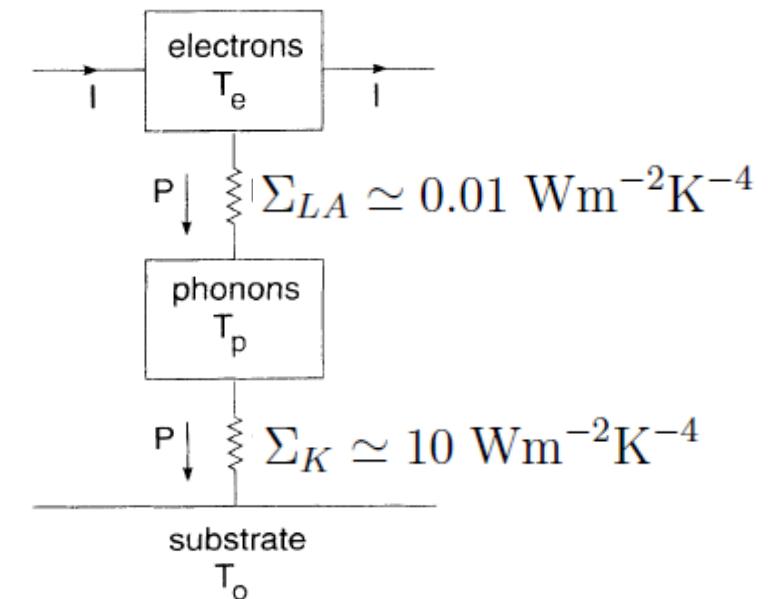


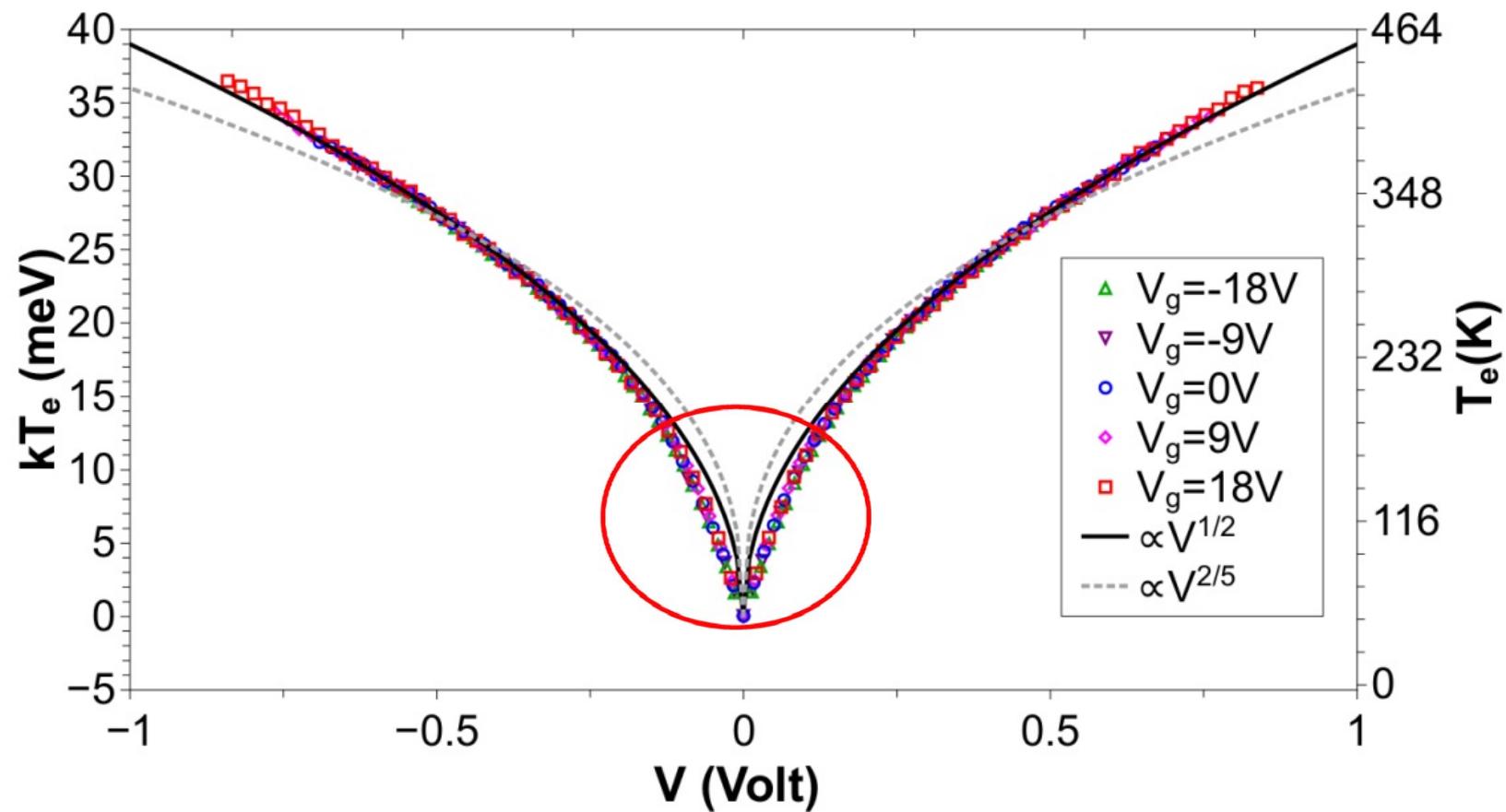
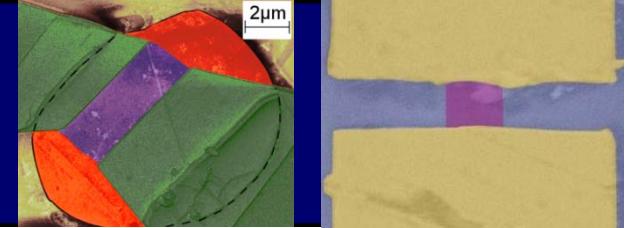
# Hot electrons but cold phonons



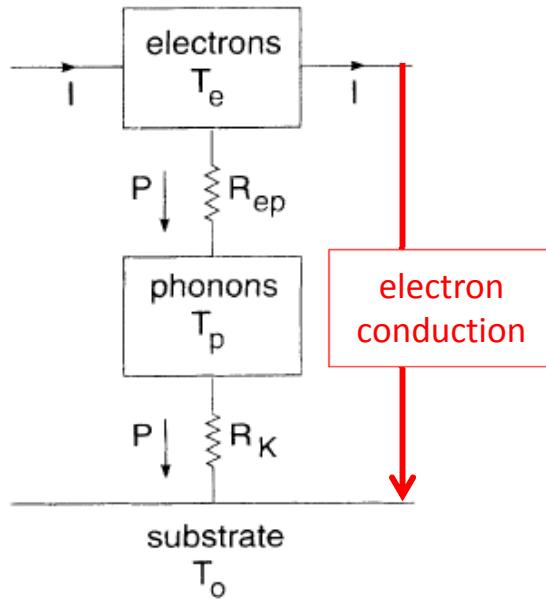
A. Betz et al., arXiv:1203.2753v1

Fabien Vialla, D. Brunel and C. Voisin



The  $P = \Sigma T^4$  dependence

# Electronic temperature profile



Heat equation, sample  $L \times W$

$$\frac{\mathcal{L}}{2R} \frac{L^2 \partial^2 T^2(x)}{\partial x^2} = -\frac{V^2}{R} + LW\Sigma [T^4(x) - T_{ph}^4]$$

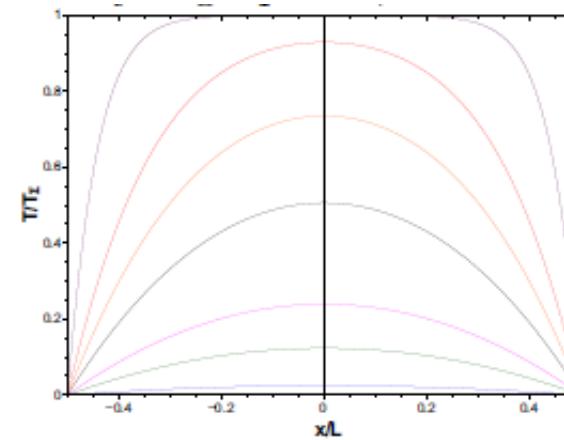
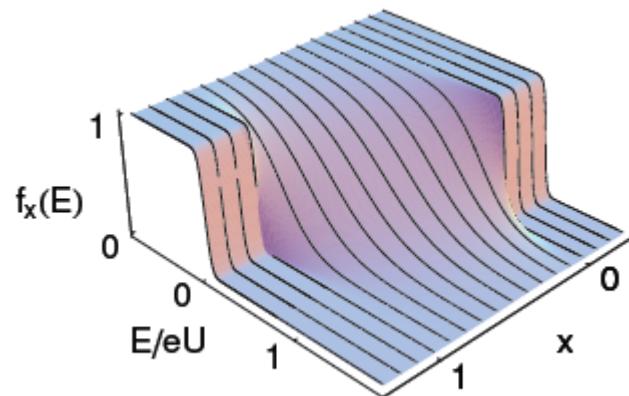
$\downarrow$

$$\mathcal{L} = \pi^2 k_B^2 / 3e^2$$

Lorenz number

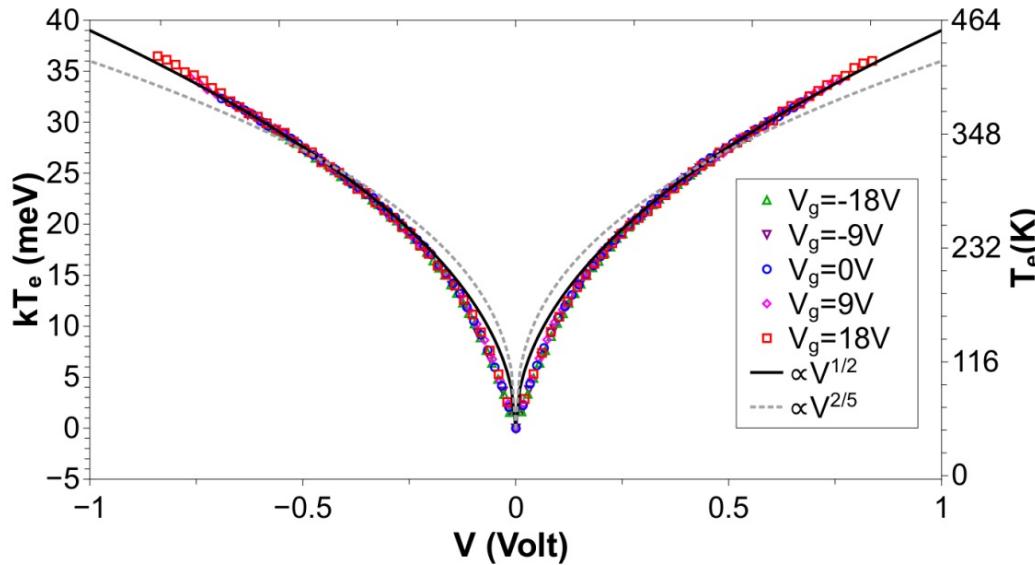
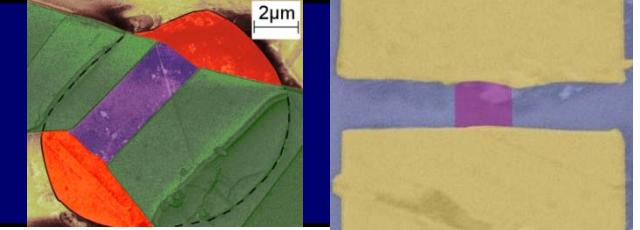
$$\Sigma_{LA} = \frac{\pi^2 D^2 k_B^4}{15\rho\hbar^5 v_F^3 c^3} \times |E_F|$$

LA-phonons coupling constant



$$T_e = \langle T(x) \rangle$$

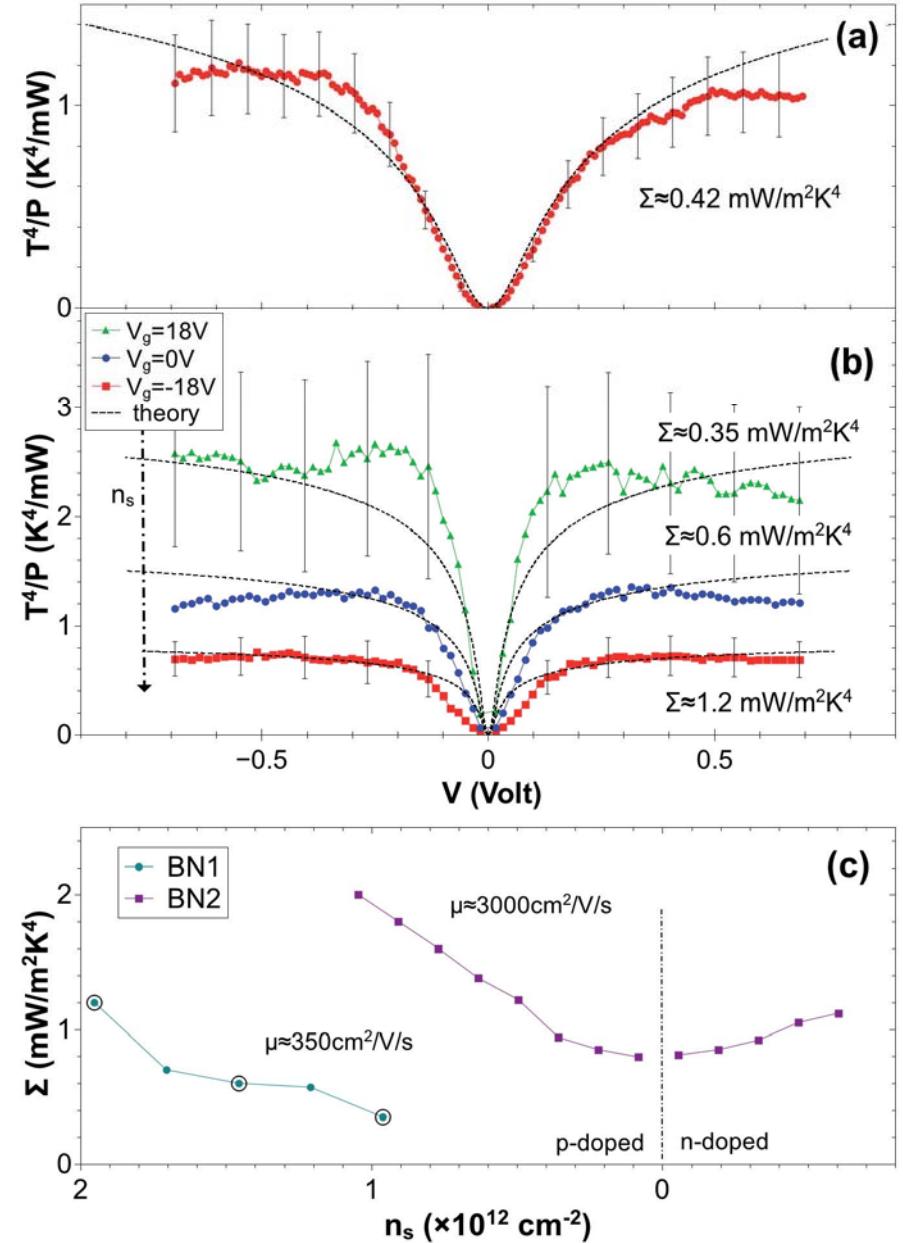
# The $P=\Sigma T^4$ dependence



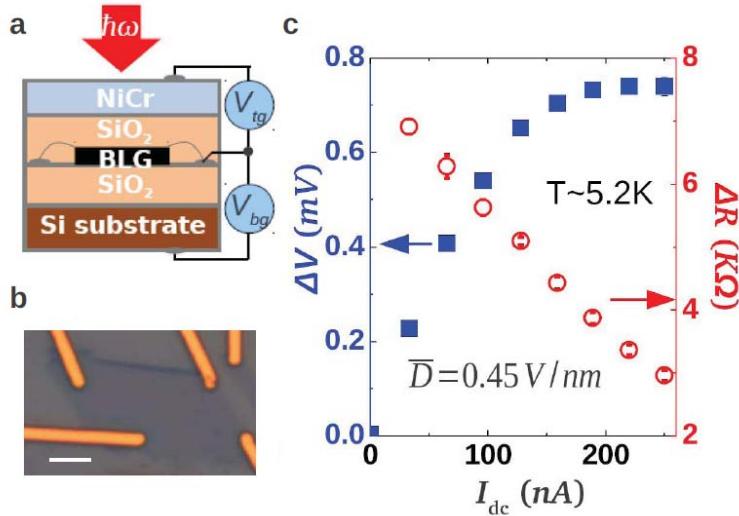
$$\frac{\mathcal{L}}{2R} \frac{L^2 \partial^2 T^2(x)}{\partial x^2} = -\frac{V^2}{R} + LW\Sigma [T^4(x) - T_{ph}^4]$$

$\Sigma \sim \Sigma_{LA}/10$  ! (lattice disorder)

ER-Tremblay, 28/06/2012

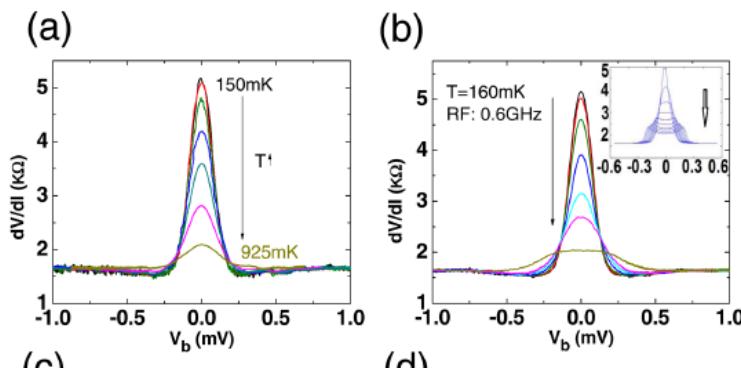


# Hot-electron bolometers

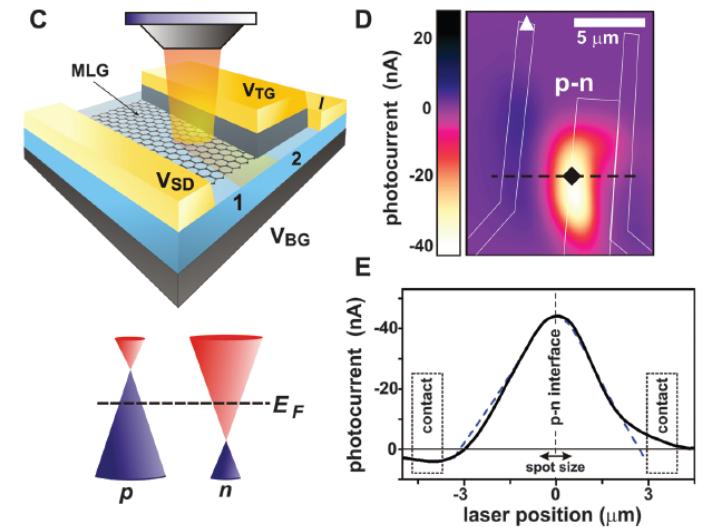


Yan et al., Nature nano 2012

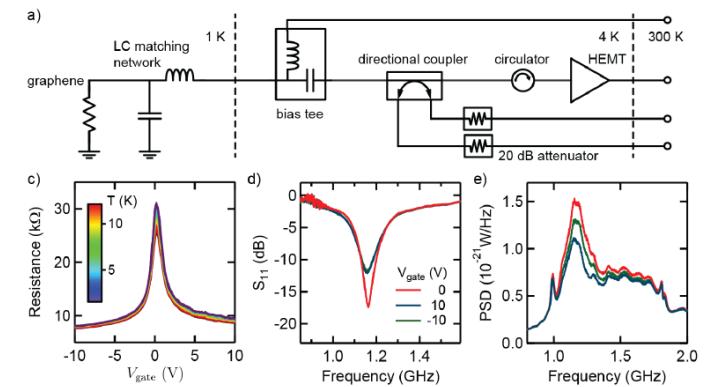
$$\Sigma_{LA} = \frac{\pi^2 D^2 k_B^4}{15\rho\hbar^5 v_F^3 c^3} \times |E_F|$$



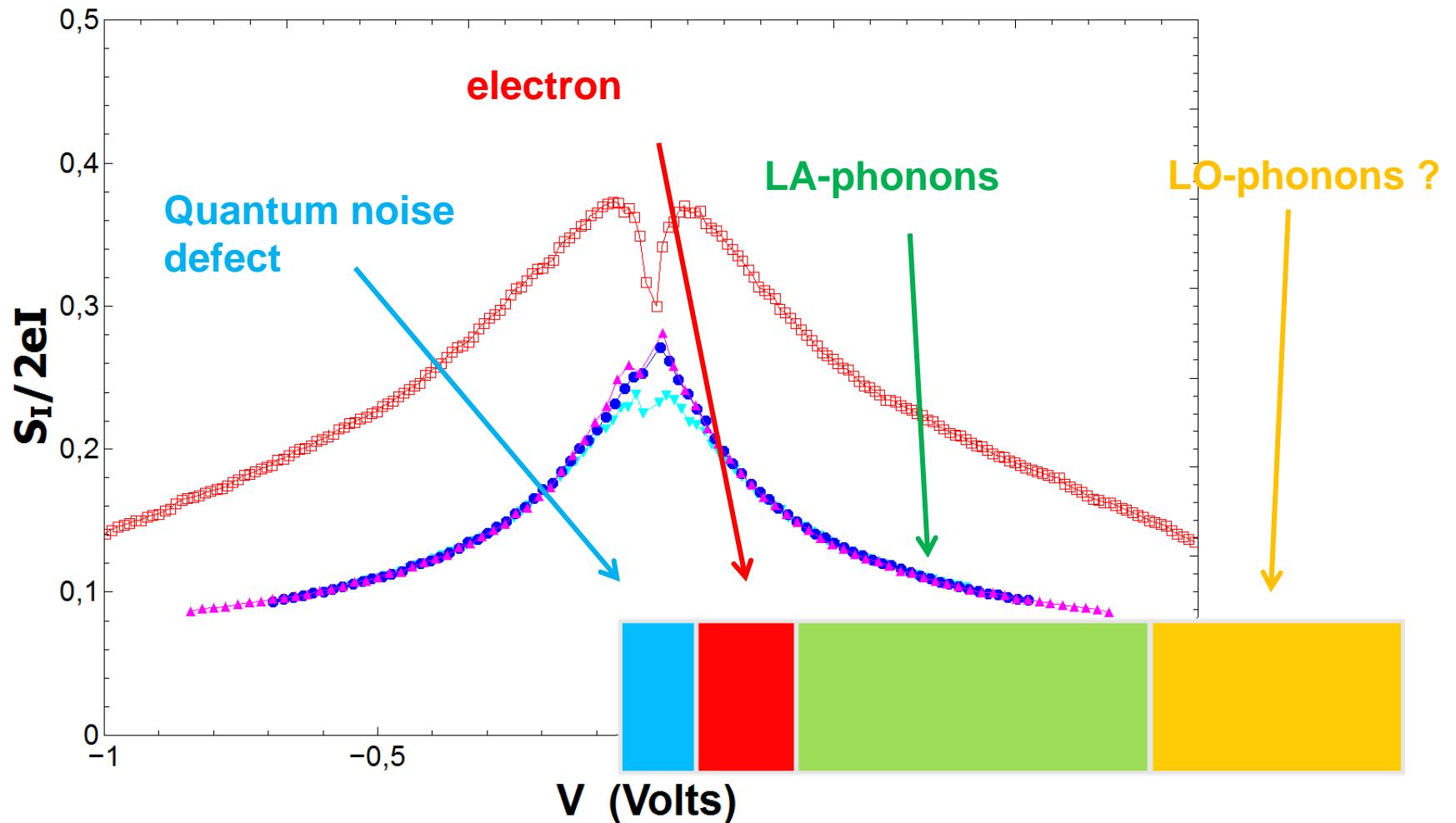
Vora et al., APL 2012  
ER-Tremblay, 28/06/2012



Gabor et al., Science 2011

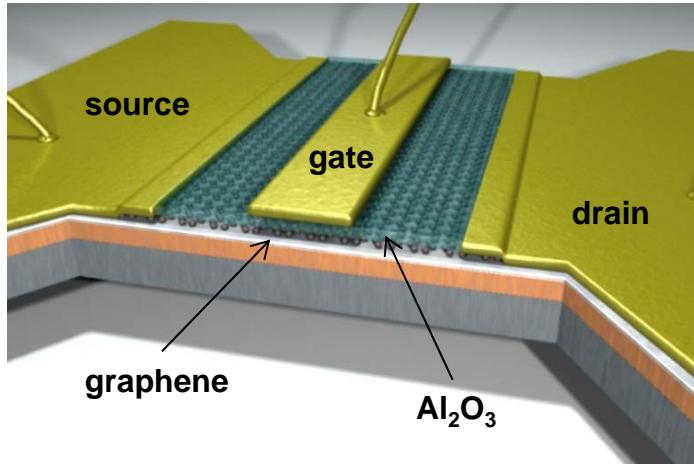


Fong-Schwab arXiv 2012

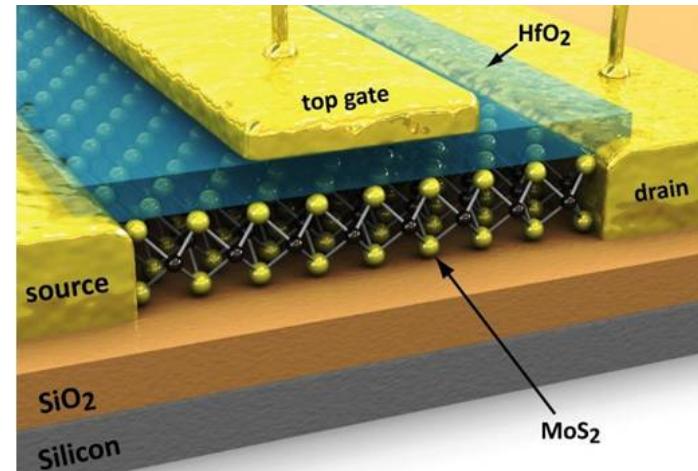


- 1) Introduction to magic graphene
- 2) Transit frequency of microwave transistors
- 3) Diffusion probed in a field-effect capacitor
- 4) Acoustic phonons controls noise of resistors
- 5) New transistor architectures

# Zoo of graphene transistors

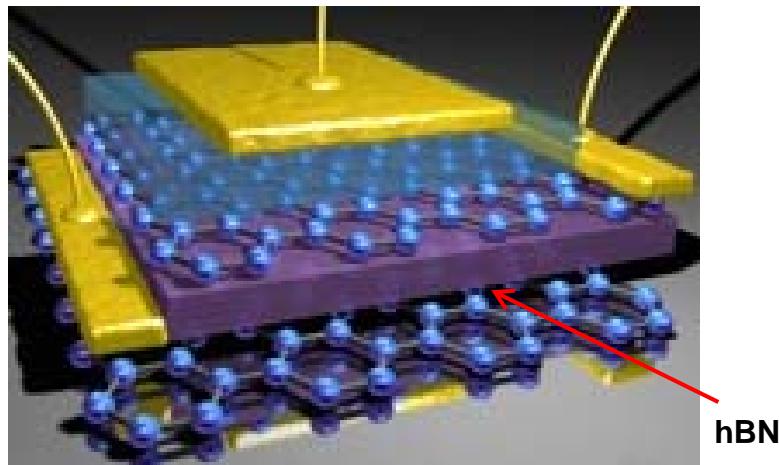


Gr-FET

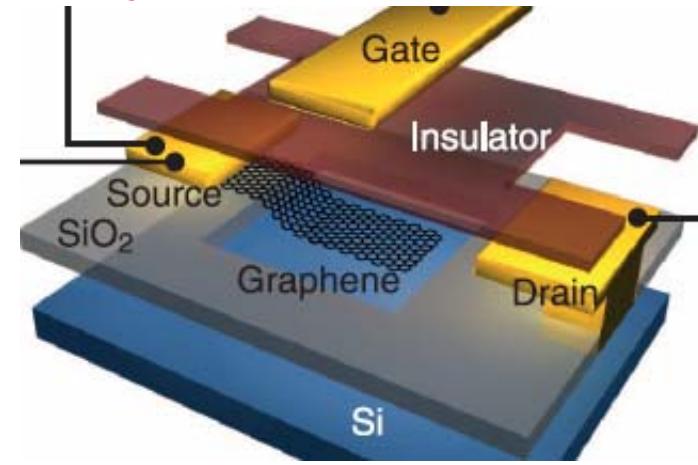


MoS<sub>2</sub>-MOSFET

(B. Radisavljevic et al. Nature nano 2011)

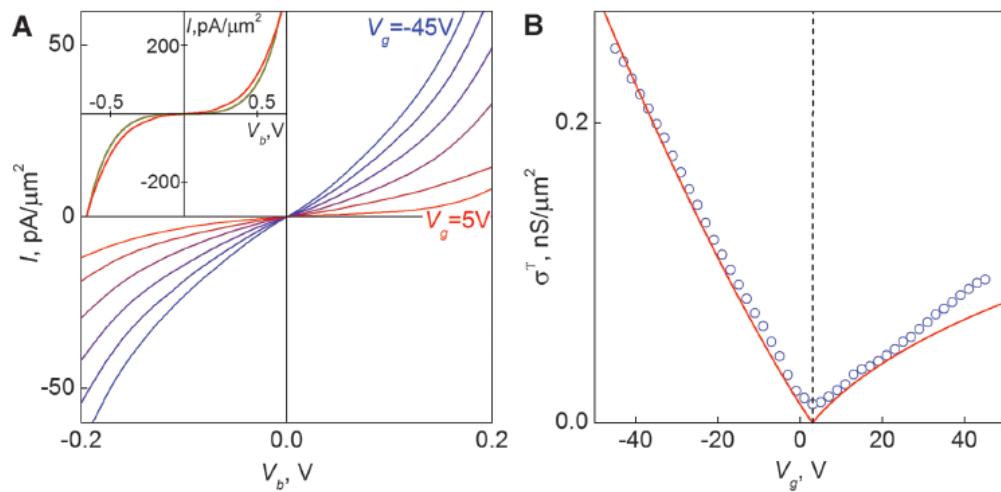
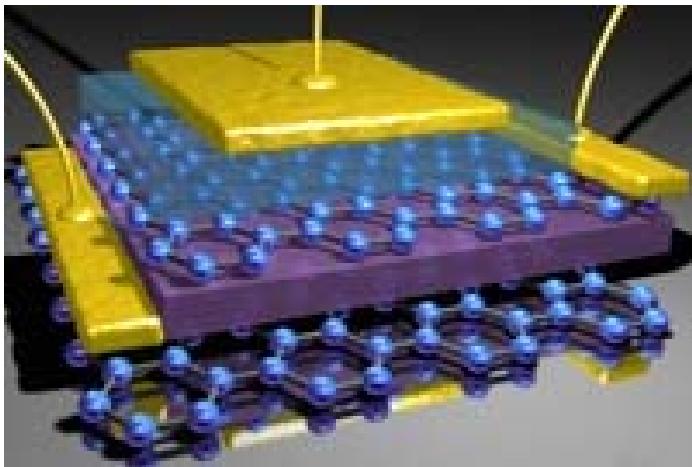


Gr/hBN (2011) - Tunnel transistor

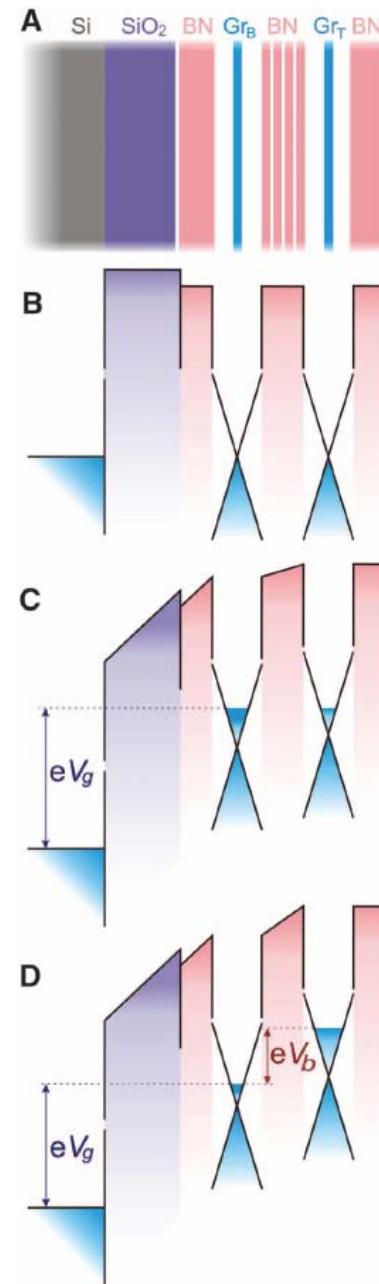


Gr/Si (2012) Shottky-transistor

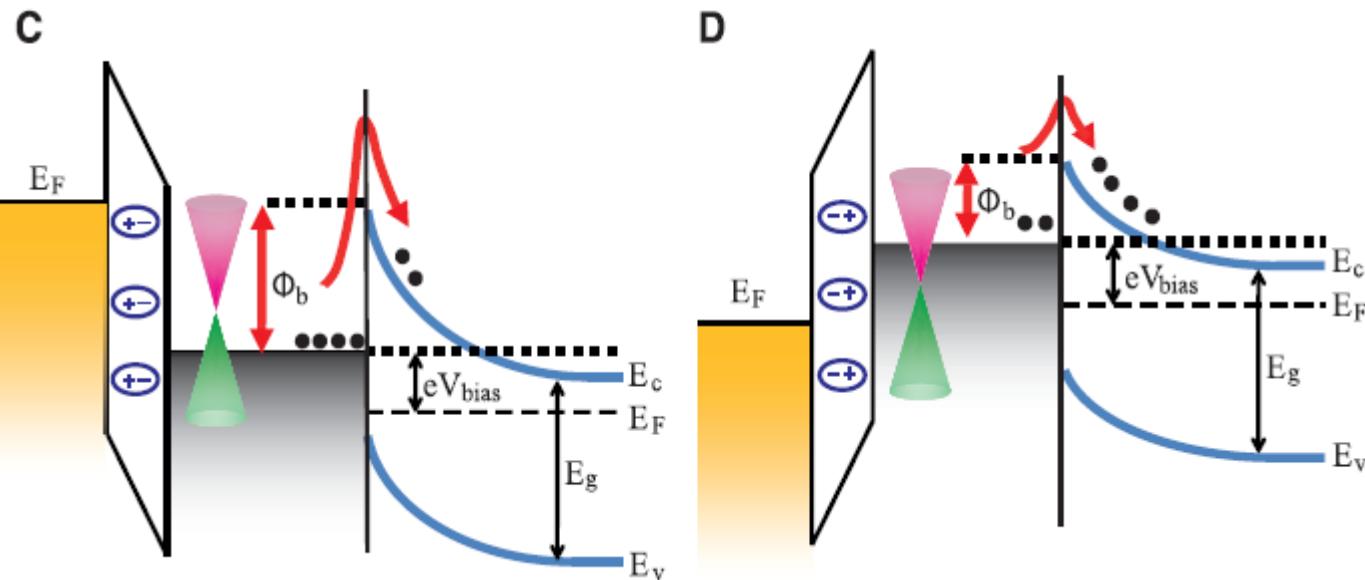
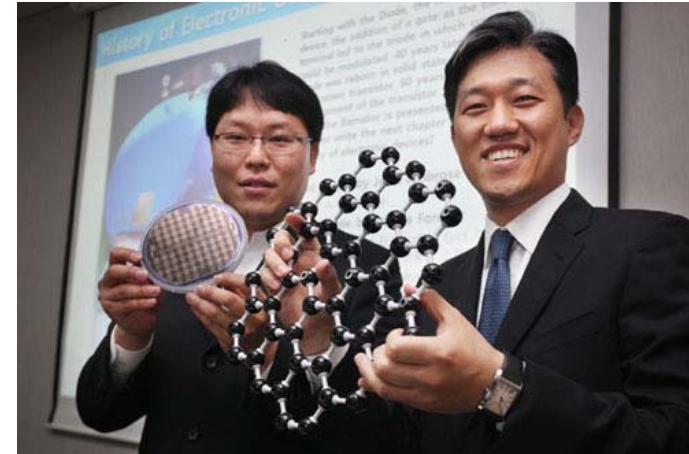
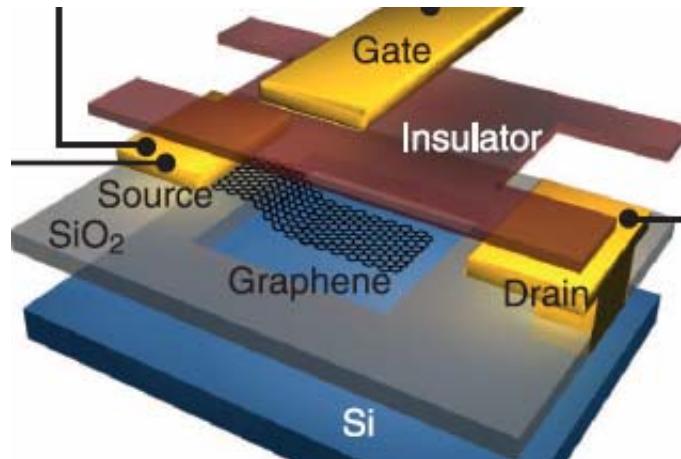
# Vertical tunnel barrier



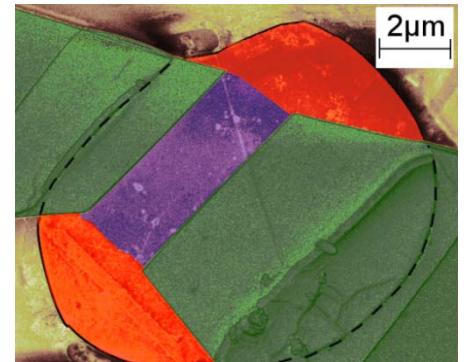
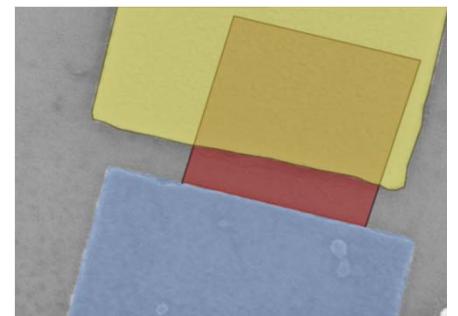
( Britnell et al. Science 2012)



# Barristor by Samsung



- Transistor: large transit frequencies
  - Capacitor : anomalous diffusion
  - Resistor : weak electron-phonon
  - Devices : High-speed LNA's, sensit



## graphene-team @ LPA



Andreas Betz



Emiliano Pallecchi



Sung-Ho Jhang



Jean-Marc Berroir



Gwendal Fève



Bernard Plaçais